

MOS-AK workshop
13 Dec. 2008

Sizing CMOS circuits by means of the g_m/I_D
methodology and a compact model.

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sizing....

find D.C. currents and transistor sizes
meeting :

- a prescribed gain-bandwidth product
- minimal power consumption
- minimal area
- large gain
-

low- voltage, low-power MOS circuits

Outline

Sizing...

- the Intrinsic Gain Stage (I.G.S.)

g_m/I_D semi-empirical methodology

g_m/I_D compact model methodology

L-V, L-P, short channel I.G.S.

- the Miller Op. Amp.

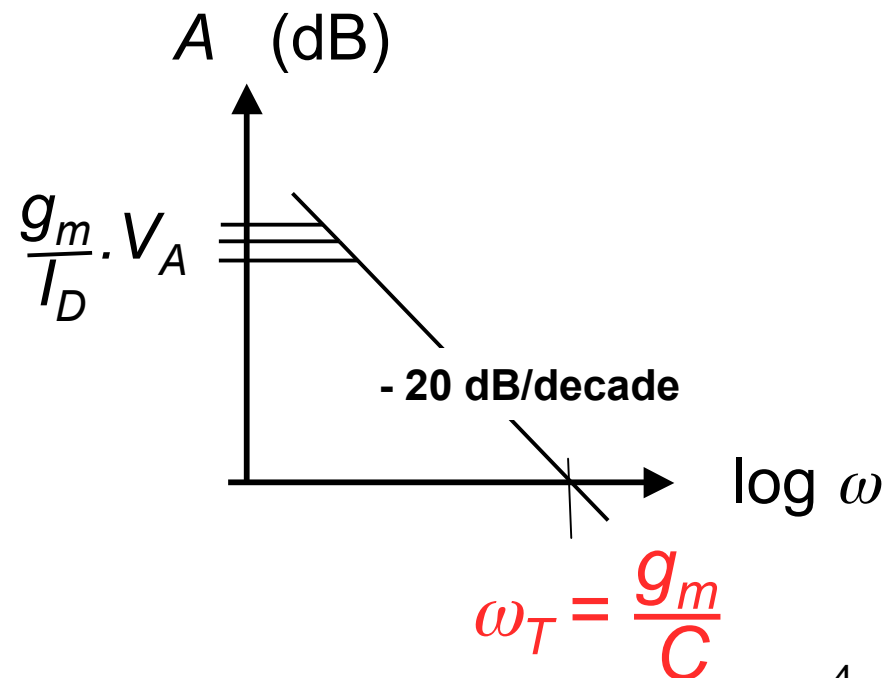
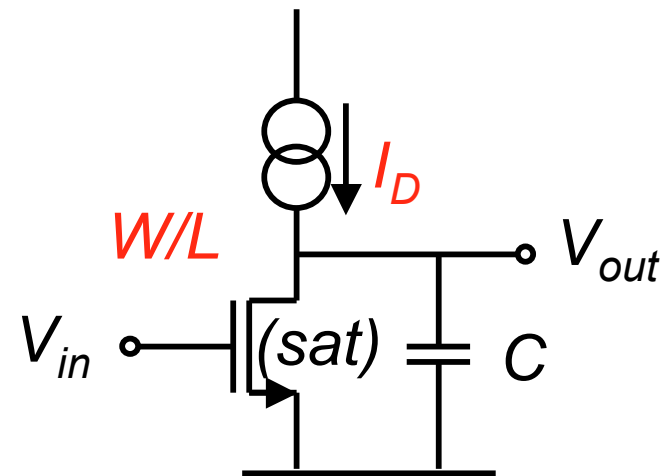
Conclusion

The Intrinsic Gain Stage (I.G.S.)

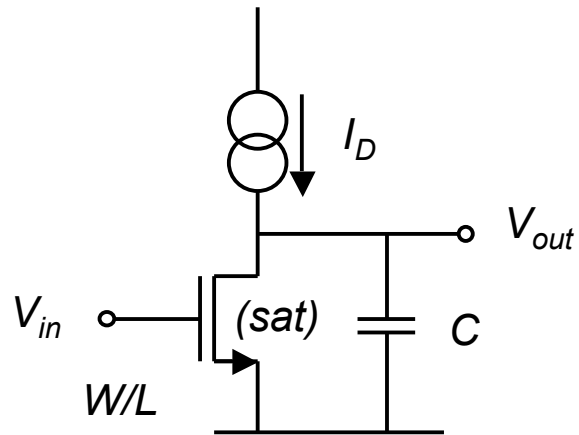
gain-bandwidth sizing:

find I_D and W/L
achieving ω_T

$$g_m = \omega_T \cdot C$$



1) (strong inversion)



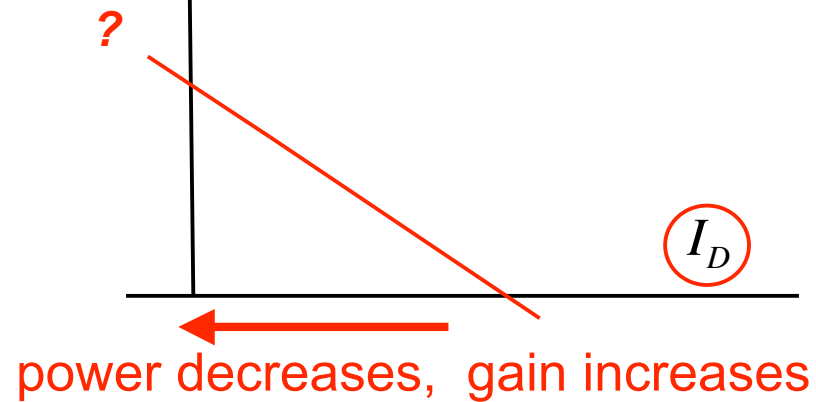
$$g_m = \omega_T C$$

$$A = \frac{g_m}{I_D} V_A = \sqrt{\frac{2\beta}{nI_D}} V_A$$

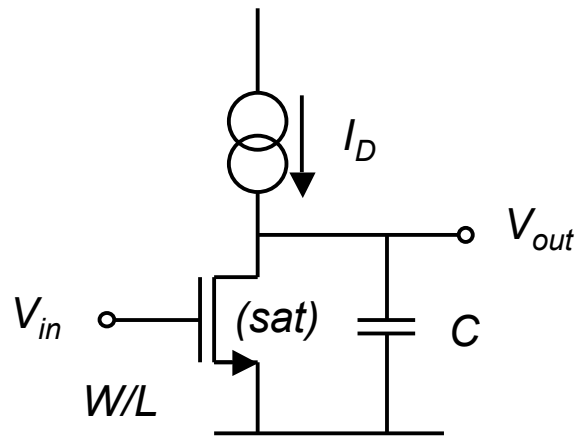
$$\beta = \mu C'_{ox} \frac{W}{L}$$

$$g_m = \frac{\partial I_D}{\partial V_G} = \sqrt{\frac{2\beta I_D}{n}}$$

$$\frac{W}{L} = \frac{n (\omega_T C)^2}{2\mu C'_{ox}} \cdot \frac{1}{I_D}$$



2) *weak inversion*)

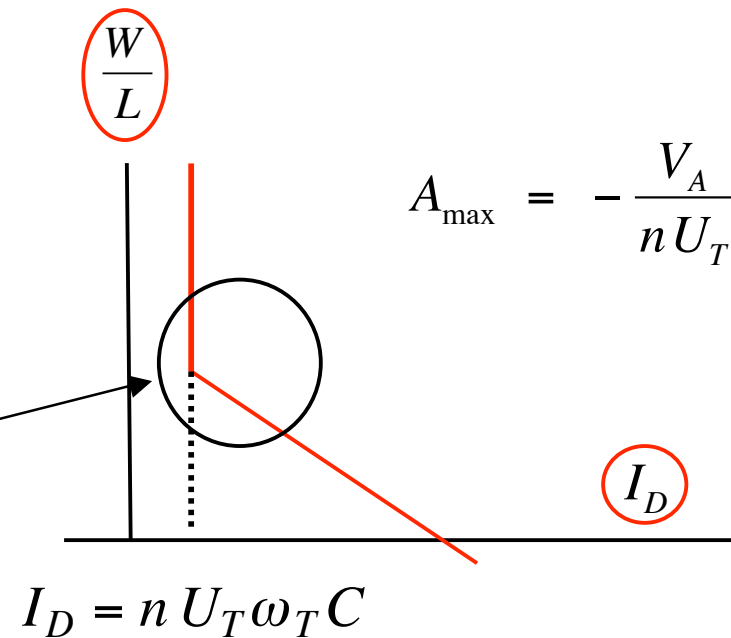


$$g_m = \omega_T C$$

$$I_D = I_o \exp\left(\frac{V_G}{nU_T}\right)$$

$$g_m = \frac{I_D}{nU_T}$$

sizing in moderate inversion?



Outline

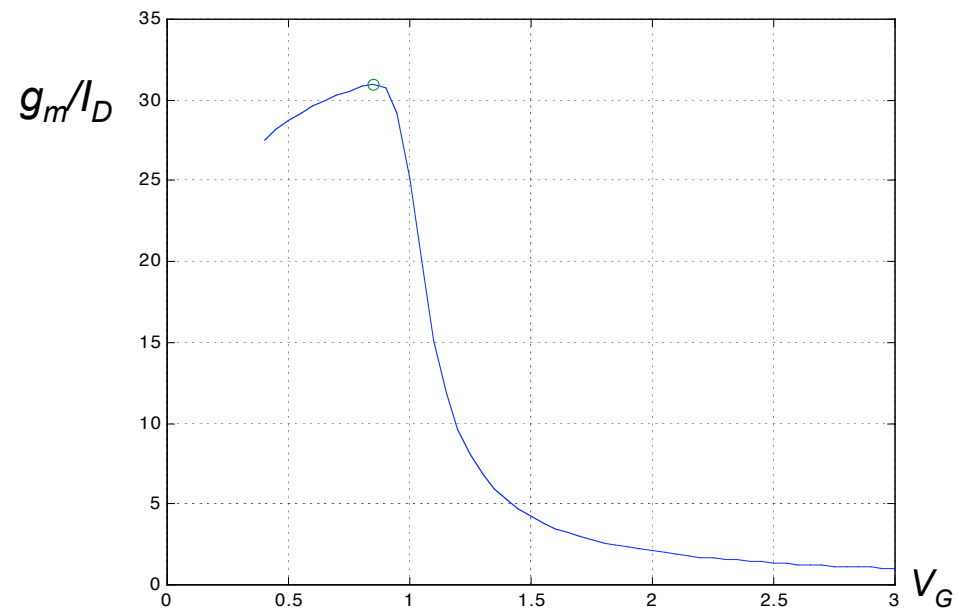
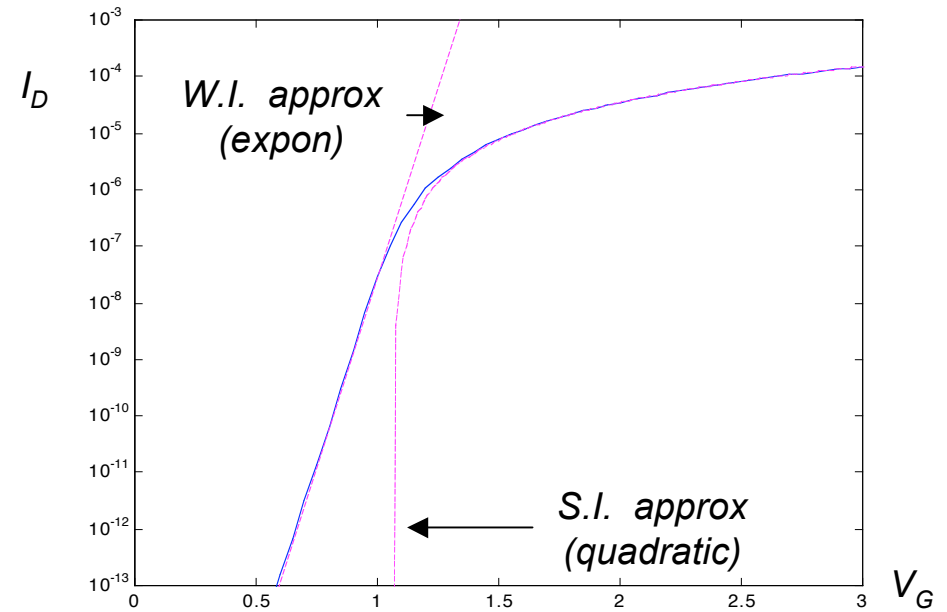
Sizing...

- the Intrinsic Gain Stage (I.G.S.)
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 - g_m/I_D compact model methodology
 - L-V, L-P, short channel I.G.S.
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Conclusion

what does g_m/I_D represent ?

$$\left(\frac{g_m}{I_D} \right) = \frac{1}{I_D} \frac{\partial I_D}{\partial V_{GS}} = \frac{\partial}{\partial V_{GS}} \log(I_D)$$



why g_m/I_D ?

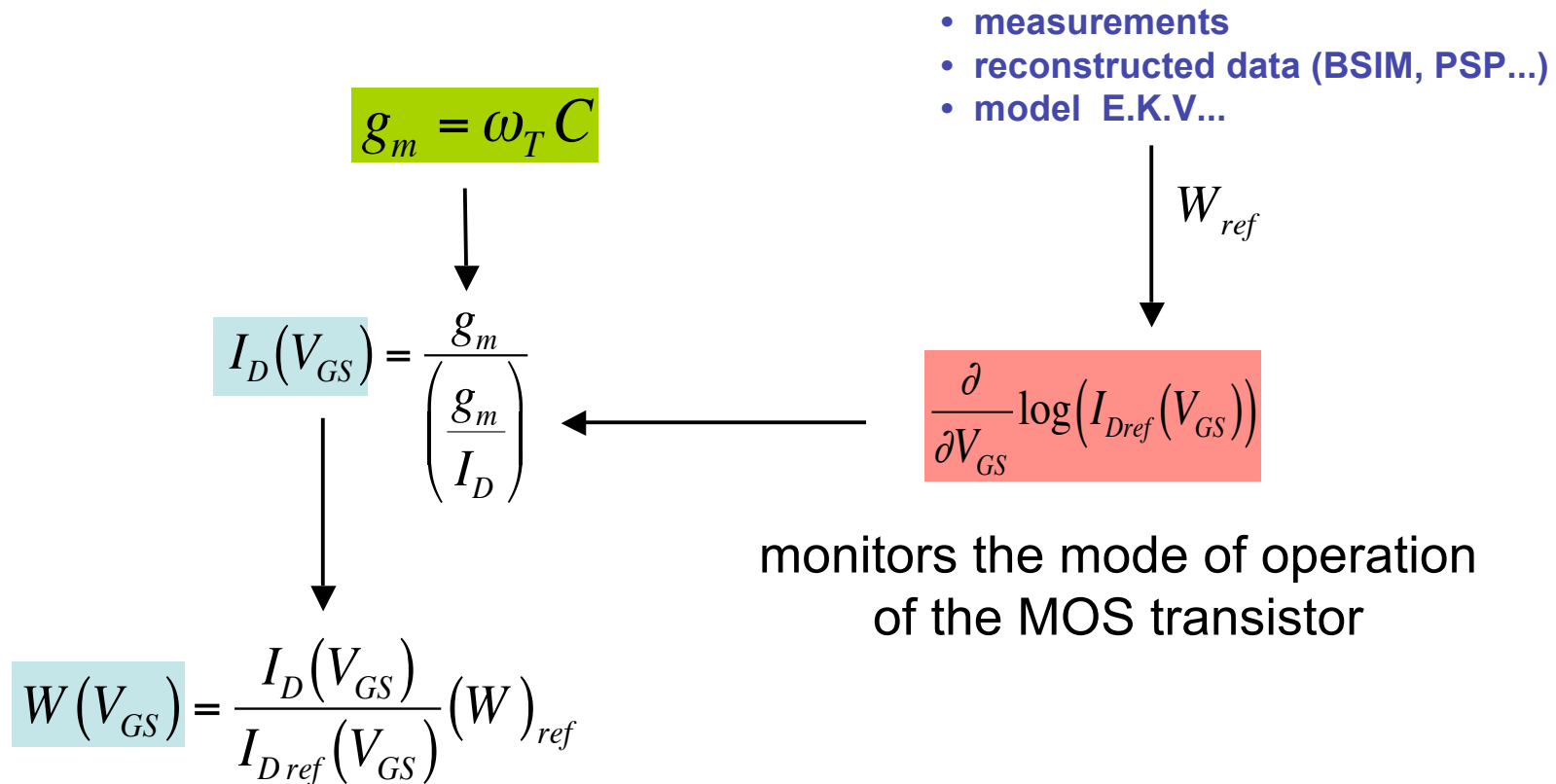
- g_m/I_D does not depend on the transistor width
 g_m and I_D are proportional to W
- g_m/I_D bridges a small signal and a large signal quantity

$$g_m \Leftrightarrow I_D$$

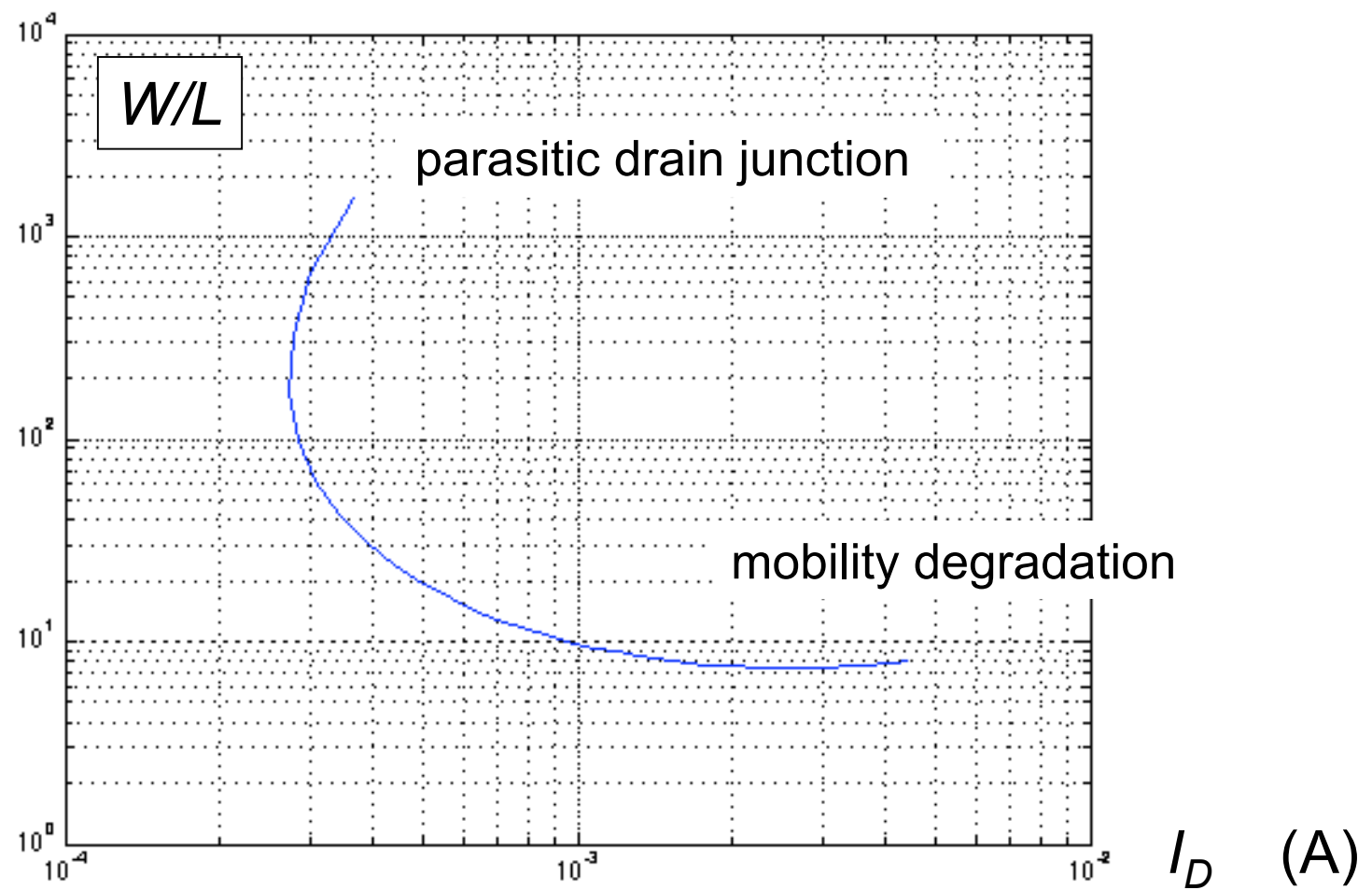
- g_m/I_D controls gain, power consumption ...

$$A = \frac{g_m}{I_D} V_A$$

The g_m/I_D sizing methodology (semi-empirical)



Example



$f_T = 1 \text{ GHz}$; $C_o = 1 \text{ pf}$; $L = 120 \text{ nm}$; $V_S = 0$; $V_{DS} = 0.6 \text{ V}$; $W_{\text{max}} = 1 \text{ }\mu\text{m}$;

First paper

A g_m/I_D Based Methodology for the Design of CMOS Analog Circuits and Its Application to the Synthesis of a Silicon-on-Insulator Micropower OTA

F. Silveira, D. Flandre, P.G.A. Jespers

IEEE JOURNAL OF SOLID STATE CIRCUITS, VOL. 31, NO. 9, SEPTEMBER 1996
p. 1314 ...

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Conclusion

The ACM and EKV compact models

- + *continuous model (saturation, weak to strong inversion)*
- + *few parameters:*
 - n subthreshold slope factor*
 - I_{Su} unary specific current*
 - V_{To} threshold voltage*
- *uniformly doped substrate, no mobility degradation,*
- *gradual channel approximation (1D)*

A.C.M.

- An **MOS transistor model** for analog circuit design
Ana I. Cunha, M.C. Schneider, C. G. Montoro.
IEEE JSSC, vol 33, n°10, oct, 1998.

E.K.V.

- An analytical **MOS transistor model** valid in all regions of operation and dedicated to Low-Voltage and Low-current applications.
Chr. C.Enz, F. Krummenacher, E. A. Vittoz.
Analog Integrated Circuits and Signal Processing, Kluwer Ac. Publ. 1995.

The compact model (1)

drain current normalization

normalized drain current

$$i = \frac{I_D}{I_S}$$

specific current

$$\underbrace{2nU_T^2 \mu C'_{ox} \frac{W}{L}}_{\text{EKV}}$$

EKV

$$I_{Su}$$

$$\frac{1}{2} n U_T^2 \mu C'_{ox} \frac{W}{L}$$

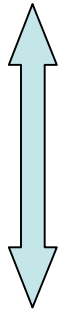
ACM

unary specific current ($W = L$)

The compact model (2)

norm. drain current (*saturation*)

$$i = q^2 + q$$

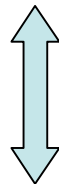


normalized mobile charge density

$$q = -\frac{Q'_i}{2nU_T C'_{ox}}$$

channel voltage

$$V_P - V = U_T [2(q - 1) + \log(q)]$$

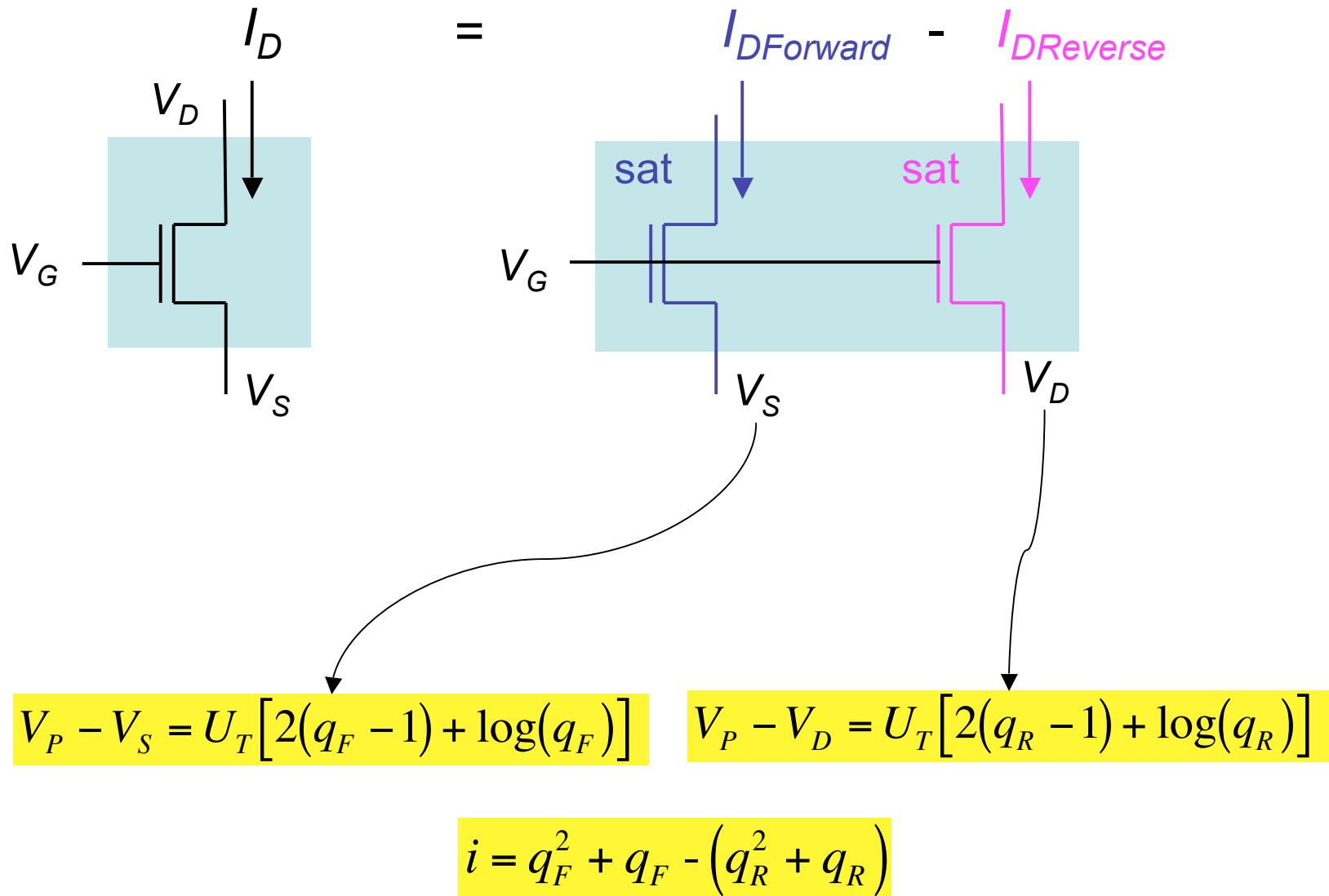


pinch - off voltage

gate voltage

$$V_P = \frac{V_G - V_{To}}{n}$$

The compact model (3)



example : $I_{Du}(V_G)$ of grounded source ($V_S = 0$ V) saturated ($q \Rightarrow q_F$) transistor

parametric method

$$q_F \left\{ \begin{array}{l} i = q_F^2 + q_F \\ V_P = U_T(2(q_F - 1) + \log q_F) \end{array} \right. \Rightarrow \begin{array}{l} I_{Du} = i I_{Su} \\ V_G = nV_P + V_{To} \end{array}$$

% data

UT = .026;

n = 1.2;

Isu = 1e-6;

VTo = 0.4;

% compute

qF = logspace(-4,1.2,50);

i = qF.^2 + qF;

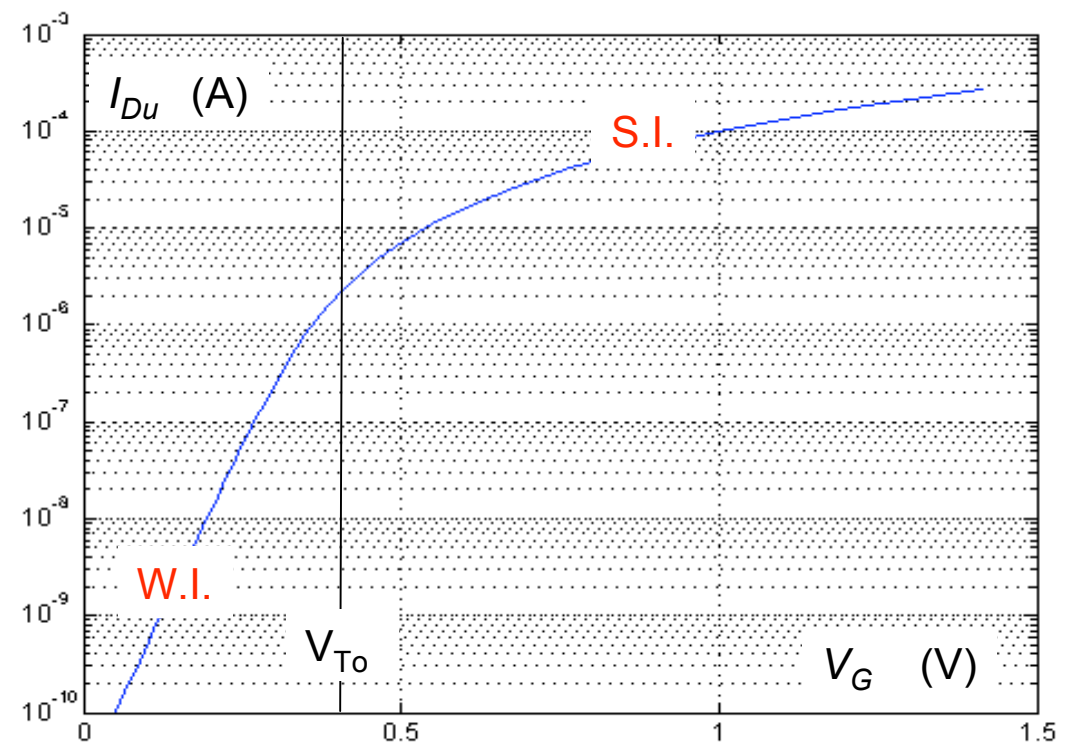
ID = i*Isu;

VP = UT*(2*(qF-1) + log(qF));

VG = n*VP + VTo;

% plot

semilogy(VG,ID); grid



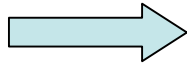
g_m/I_D of the saturated transistor

$$\frac{g_m}{I_D} = \frac{d \log(i)}{dV_G} \quad \left\{ \begin{array}{l} d \log(i) = \frac{di}{i} = \frac{2q_F + 1}{i} dq_F \\ \text{and} \\ dV_G = n dV_P = nU_T \left(2 + \frac{1}{q_F} \right) dq_F = nU_T \frac{2q_F + 1}{q_F} dq_F \end{array} \right.$$

$$\frac{g_m}{I_D} = \frac{1}{nU_T} \frac{q_F}{i} = \frac{1}{nU_T} \frac{1}{q_F + 1}$$

sizing the Intrinsic Gain Stage by means of the
E.K.V. model

E.K.V. param



```
% data
fT = 1e8;
C   = 1e-12; } specs
```

```
n   = 1.2;
Isu = 1e-6;
VTo = 0.4;
```

g_m/I_D sizing



```
% compute
```

```
UT = .026;
ωT = 2*pi*fT;
gm = ωT*C;
```

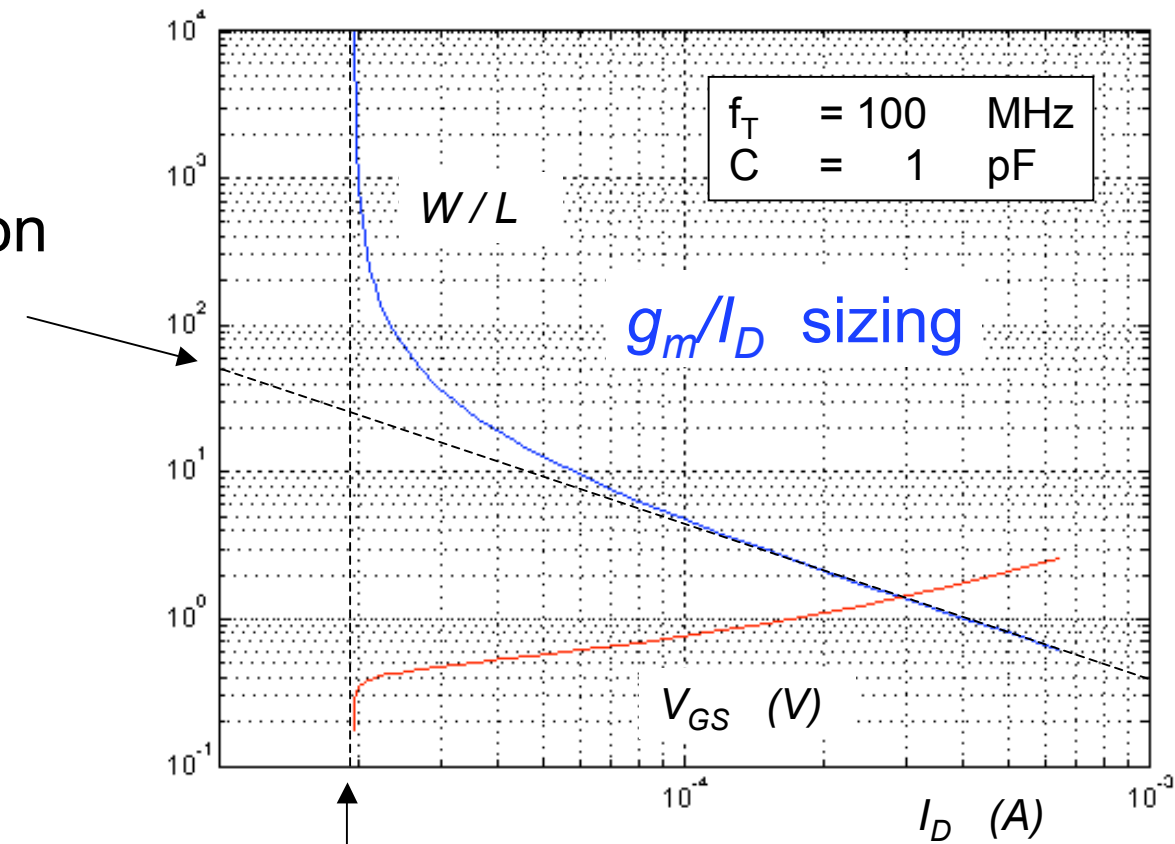
```
qF = logspace(-4,1.5,50);
gmoverID = 1./(n*UT*(1+qF));
ID = gm./gmoverID;
IDu = Isu*(qF.^2 + qF);
WsL = ID./IDu;
VP = UT*(2*(qF+1) + log(qF));
VG = n*VP + VTo;
```

```
% plot
```

```
loglog(ID,WsL,'b',ID,VG,'r');
```

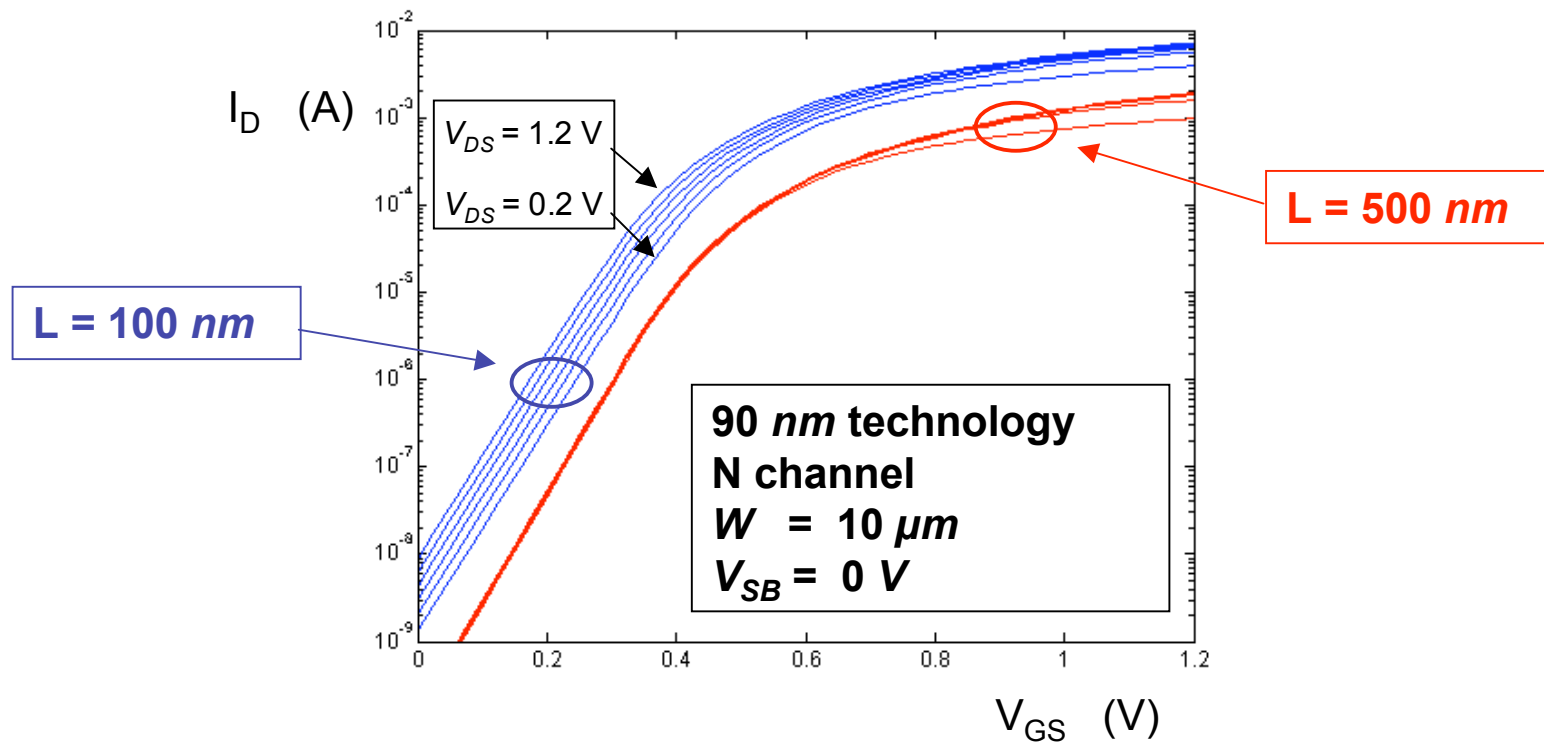
sizing the Intrinsic Gain Stage by means of the
E.K.V. model

strong inversion
approx.

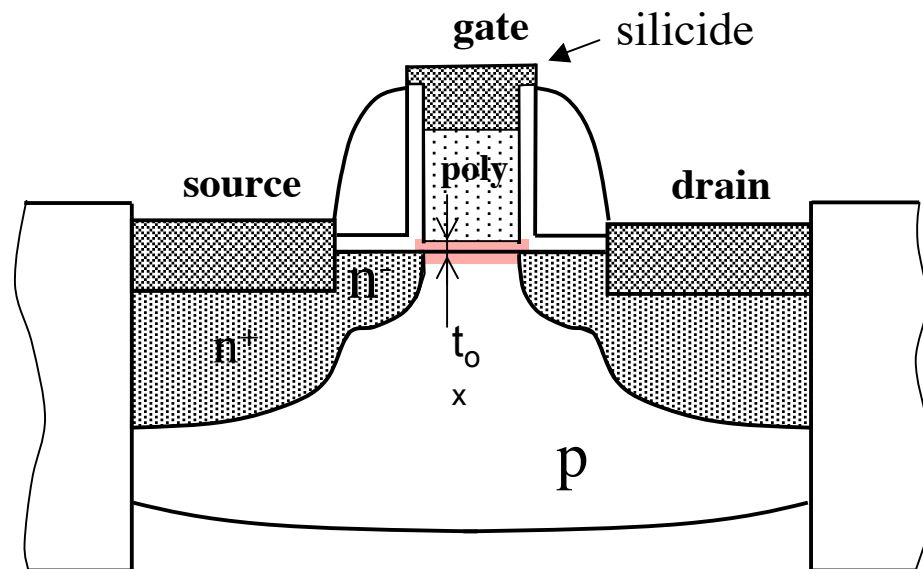


weak inversion approx.

- The basic EKV / ACM model does not apply to short channel devices!
- Real $I_D(V_{GS})$ characteristics however look very similar.



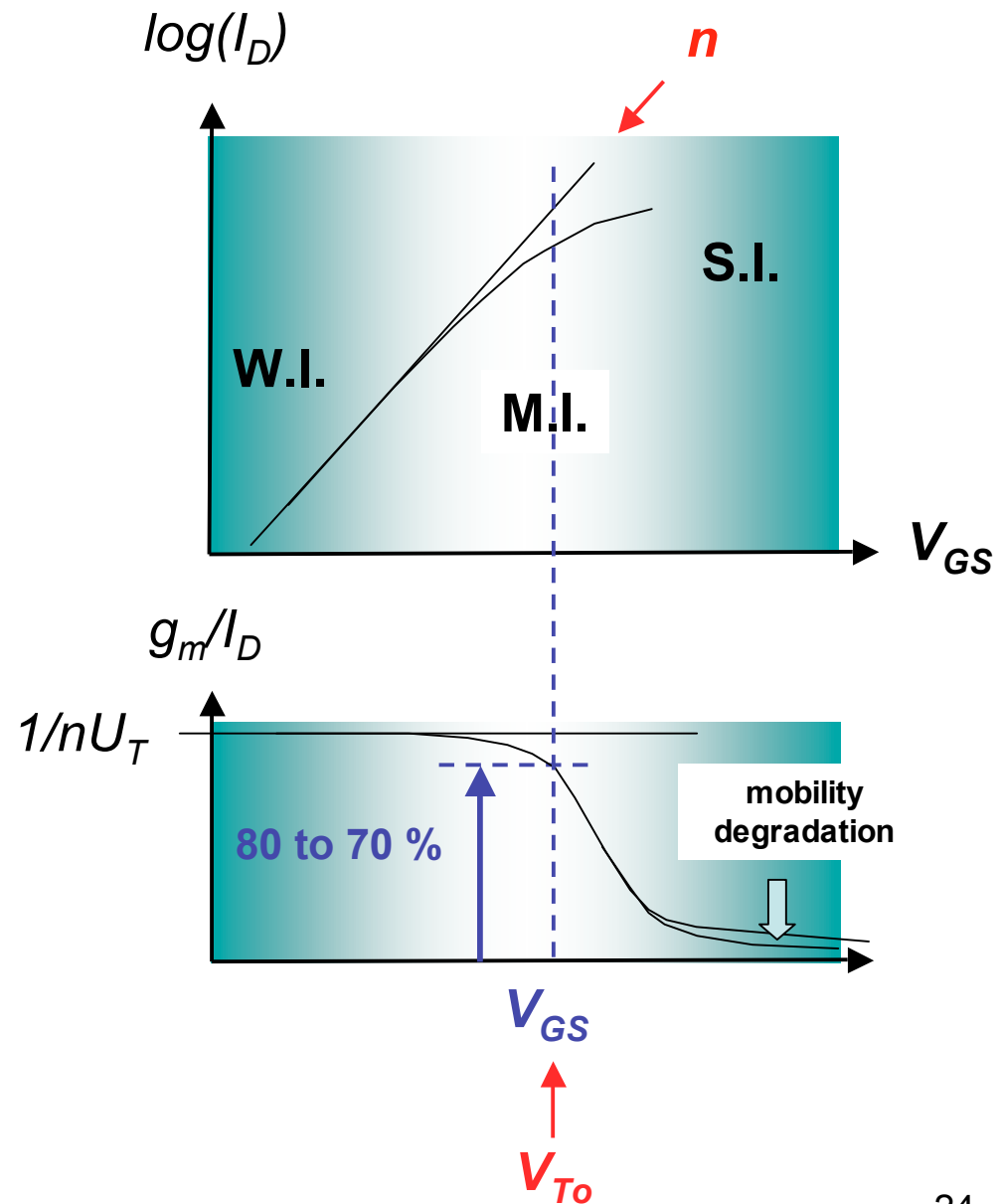
- The spatial distribution of electrical fields in the substrate boils down to a **2D** problem controlled mainly by L , V_{SB} , V_{DS} , little by V_{GS} .
- The inversion layer confines to a **1D** problem controlled by V_{GS} and L , V_{SB} , V_{DS} .
- Is it possible to model $I_D(V_G)$ characteristics by means of the EKV / ACM model with parameters that are functions of L , V_S and V_D ?



E.K.V. Identification

to be performed in the
common source configuration

For L , V_S and V_{DS}

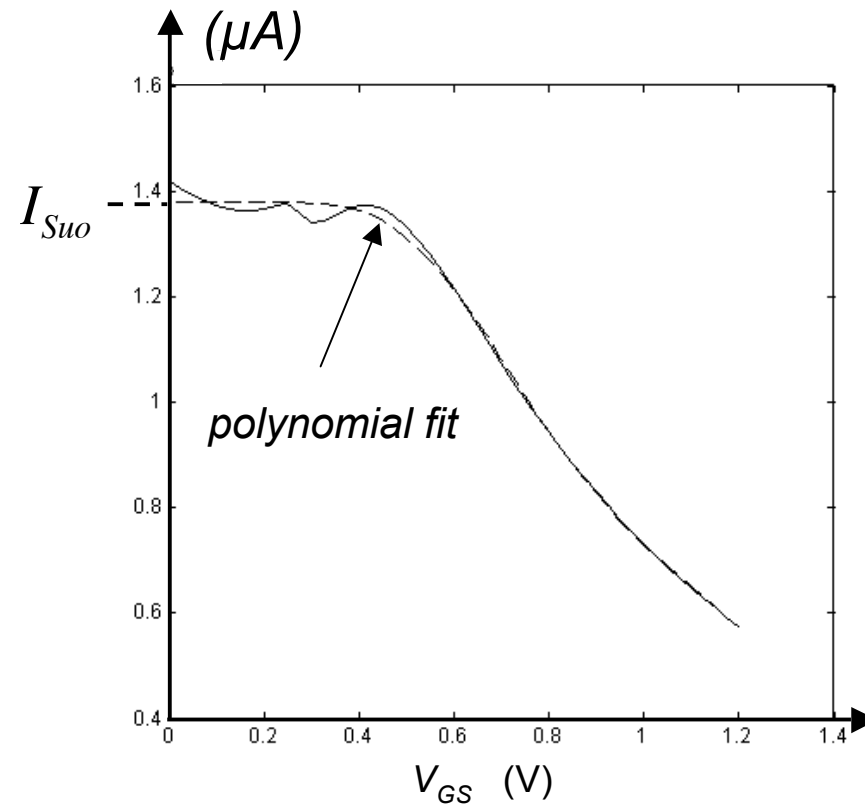


I_{su} (specific current)

$$\frac{V_{GS} - V_{To}}{n} = V_P \rightarrow q \nearrow \frac{I_{Du}(V_{GS})}{i} = I_{Su}(V_{GS})$$

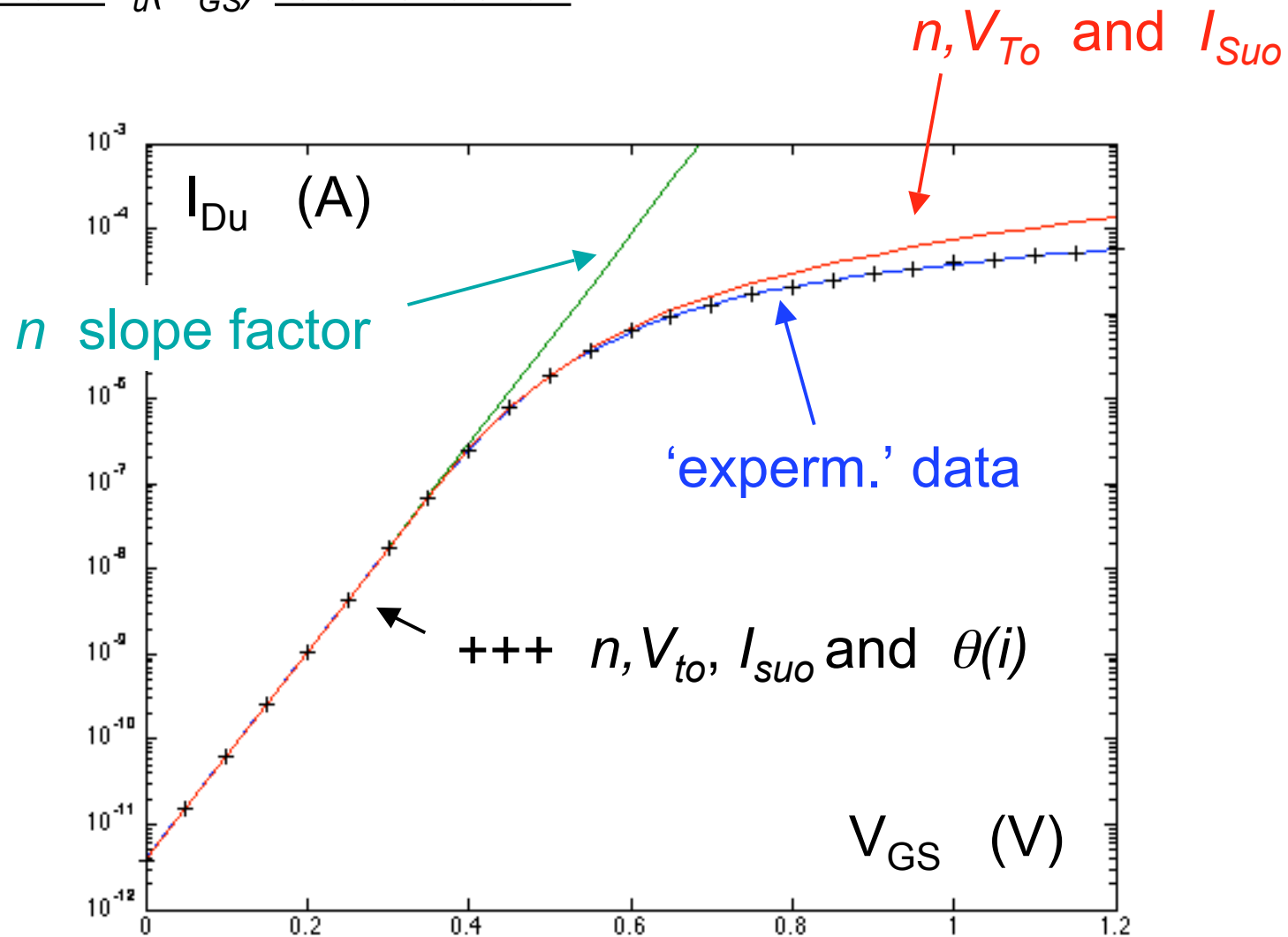
$$I_{Su} = \underbrace{2nU_T^2 \mu_o C'_{ox}}_{I_{Suo}} \theta(i)$$

mobility degradation factor

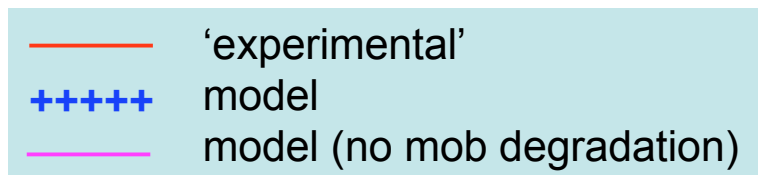
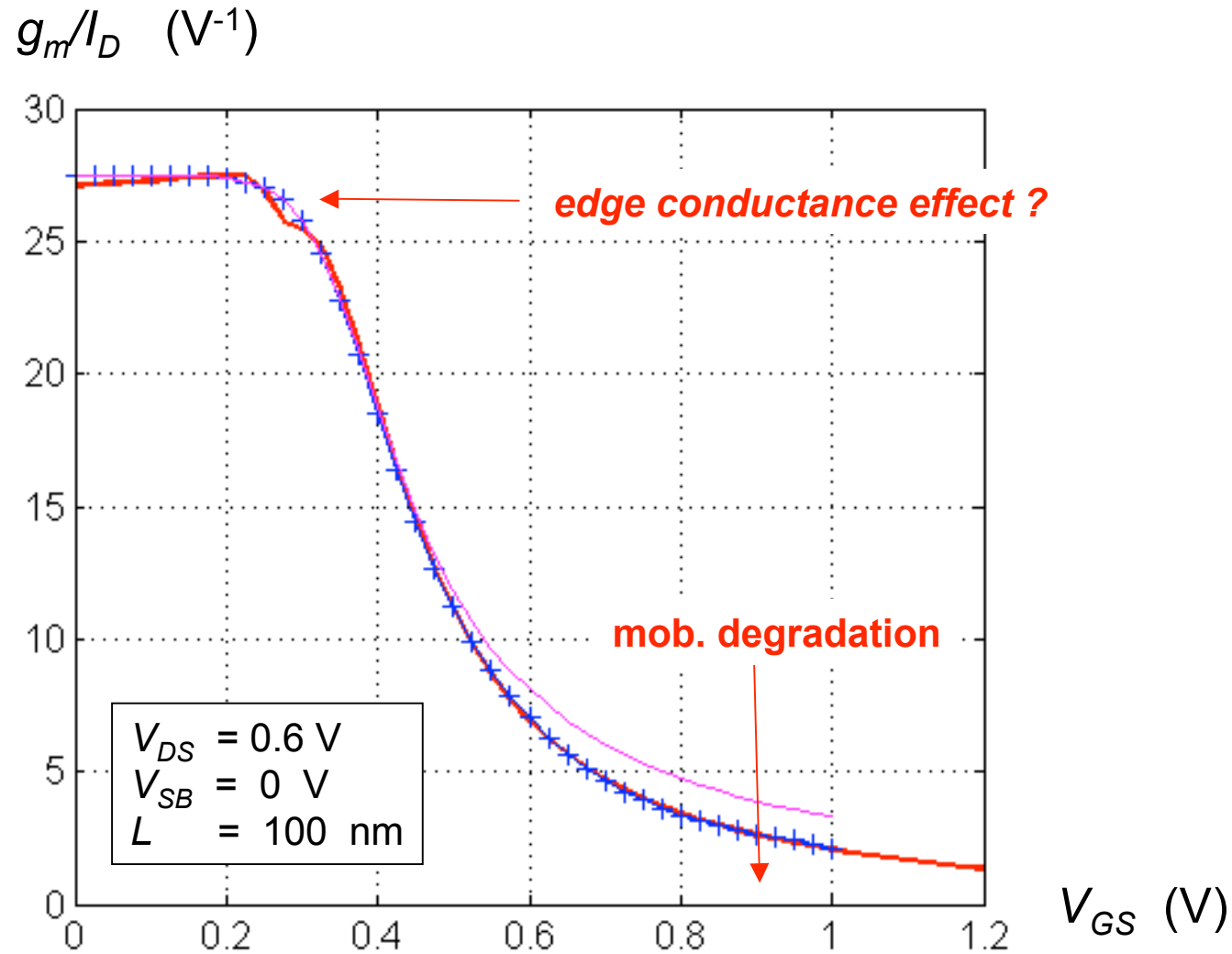


For L , V_S and V_{DS}

Verification : $I_u(V_{GS})$ reconstruction



N-channel; $L = 100$ nm; $V_{DS} = 0.6$ V; $V_{SB} = 0.6$ V.



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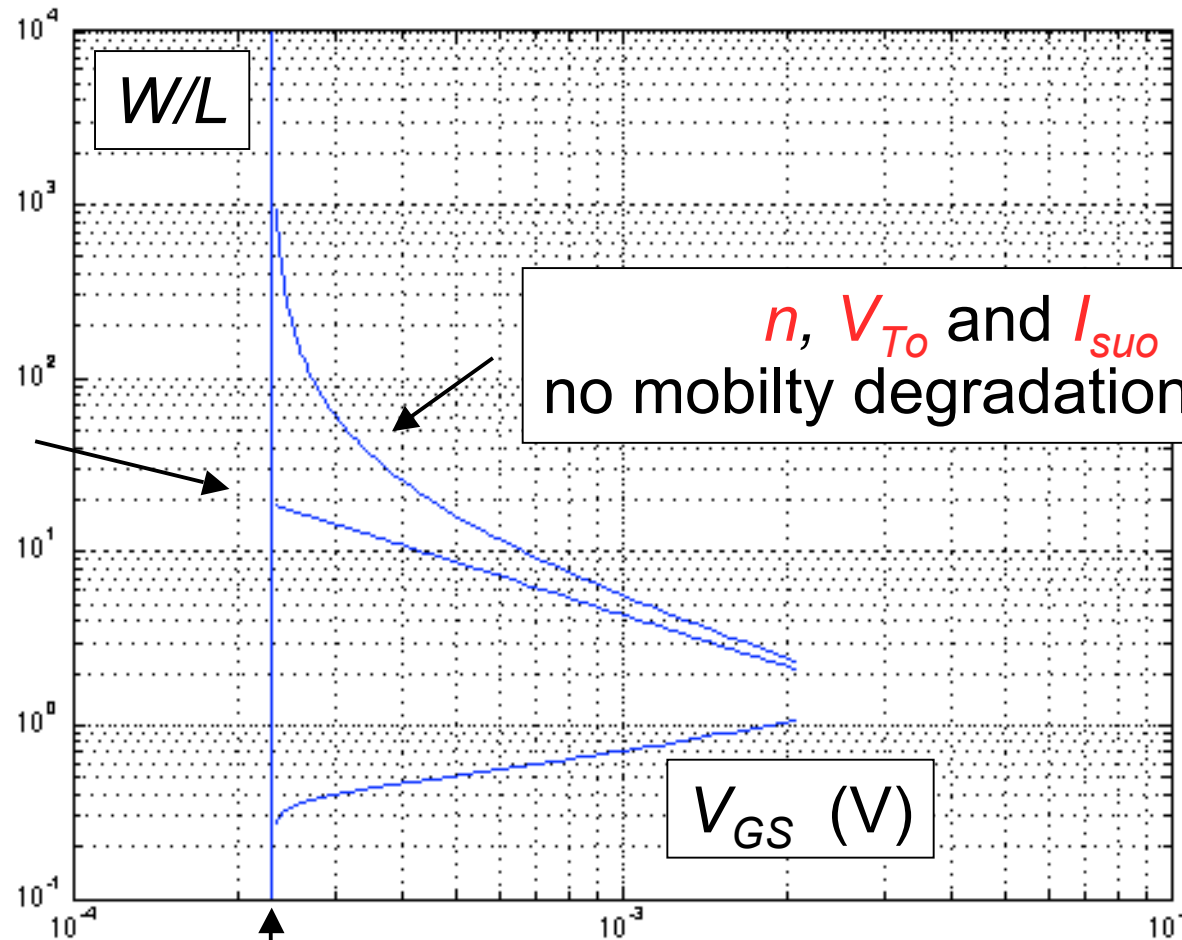
$\frac{g_m}{I_D}$ does not depend on W
as long as $W \gg W_{min}$
(true for most analogue circuits)

depends on L , V_{DS} and V_{SB} for

- V_T roll-off
- D.I.B.L.
- C.L.M.
- mobility degradation
-

$f_T = 1 \text{ GHz}$; $C_o = 1 \text{ pf}$; $L = 120 \text{ nm}$; $V_S = 0$; $V_{DS} = 0.6 \text{ V}$;

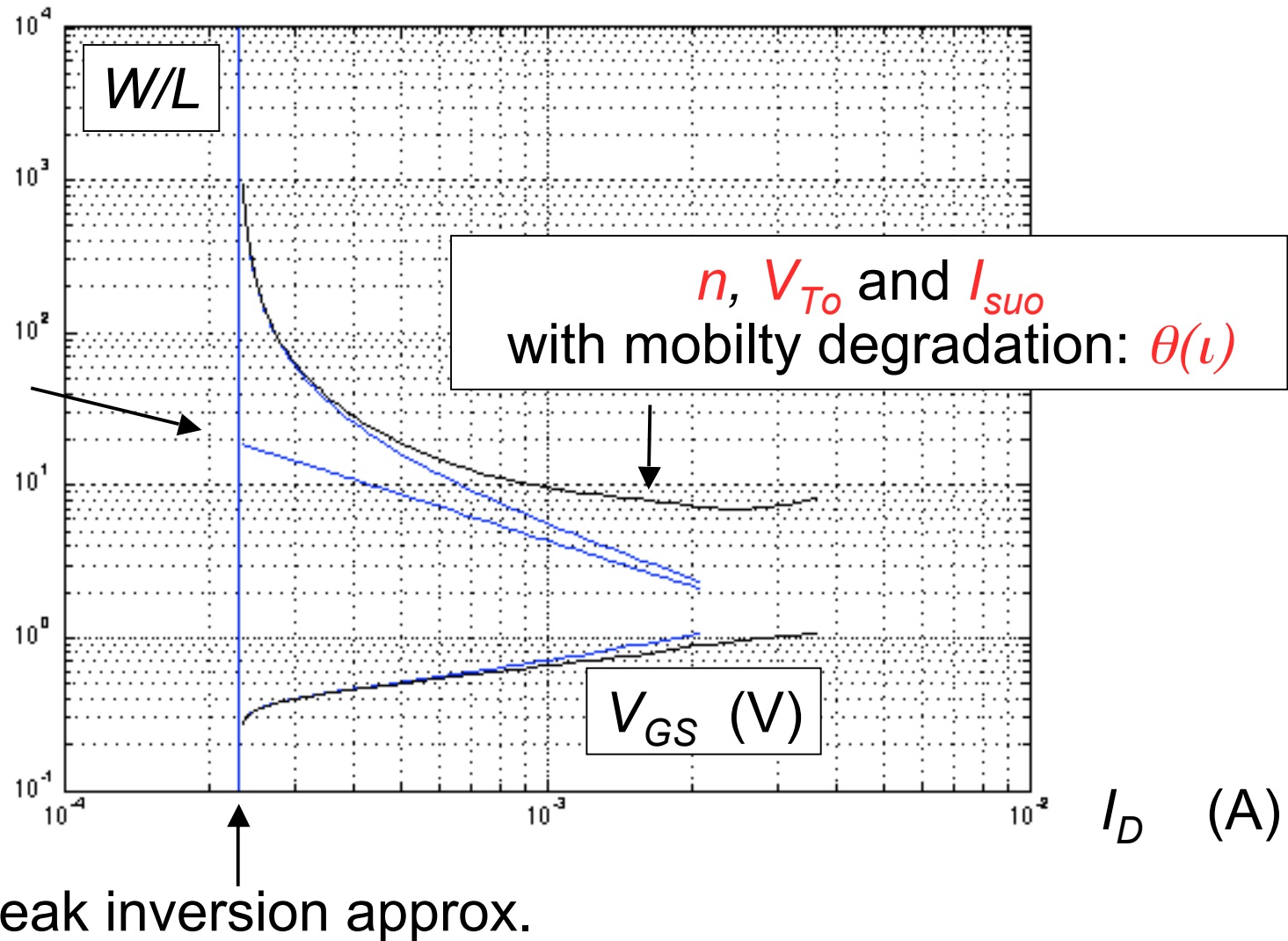
strong
inversion
approx.



weak inversion approx.

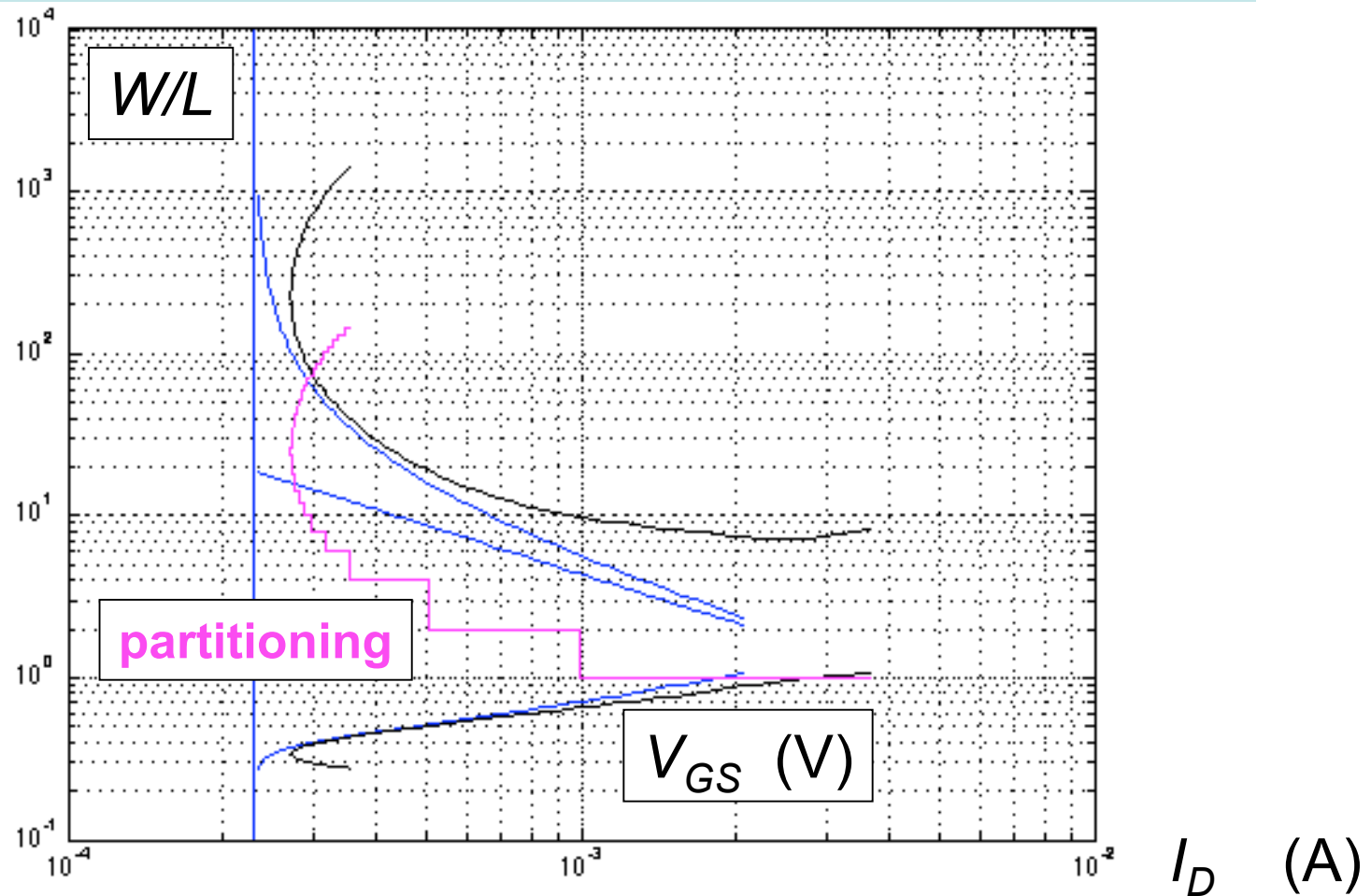
$f_T = 1 \text{ GHz}$; $C_o = 1 \text{ pf}$; $L = 120 \text{ nm}$; $V_S = 0$; $V_{DS} = 0.6 \text{ V}$;

strong
inversion
approx.



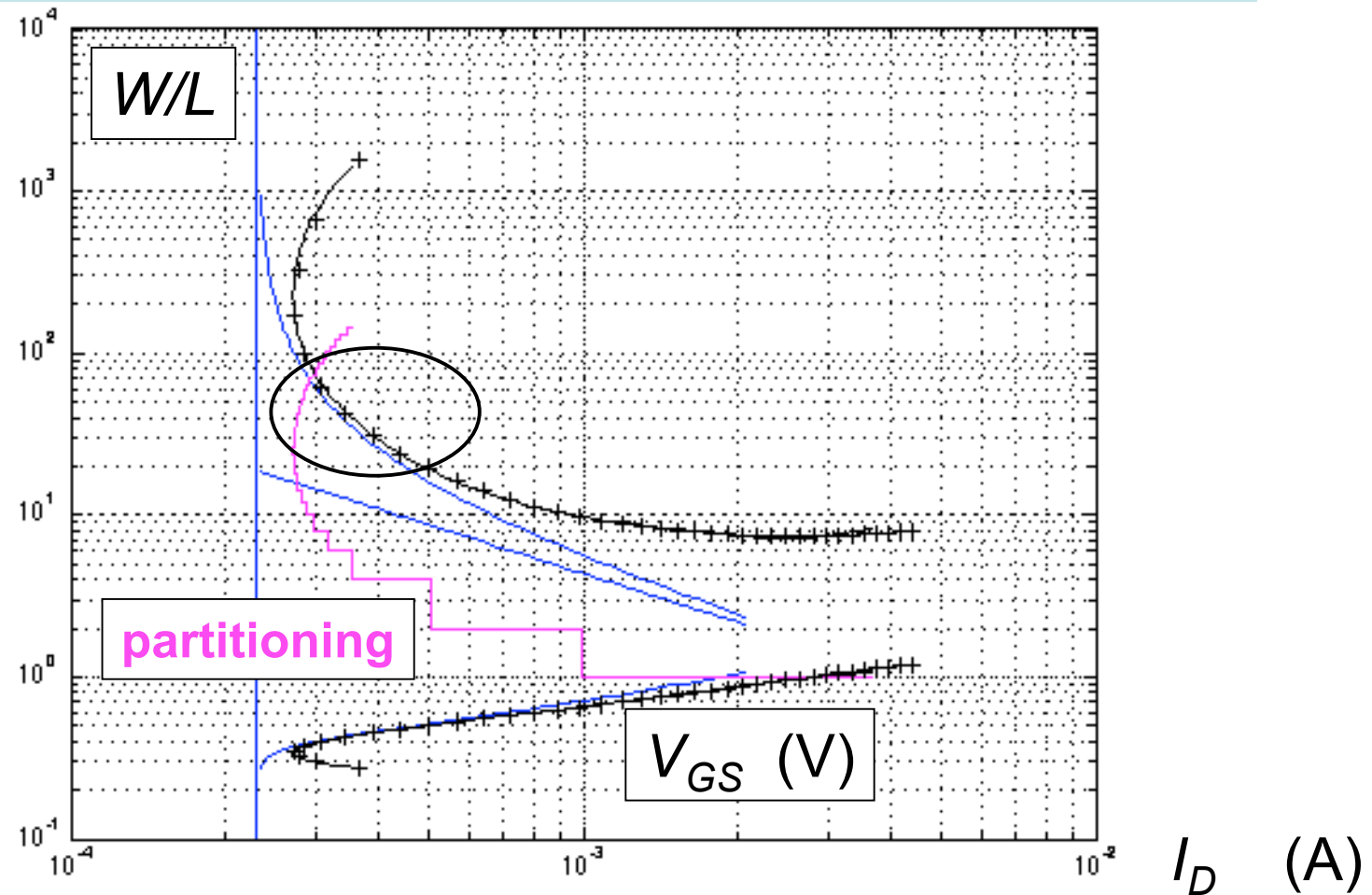
Add drain junction cap. to C_o

$f_T = 1$ GHz; $C_o = 1$ pf; $L = 120$ nm; $V_S = 0$; $V_{DS} = 0.6$ V; $W_{max} = 1$ μ m;



Comparison with semi-empirical method (+++)

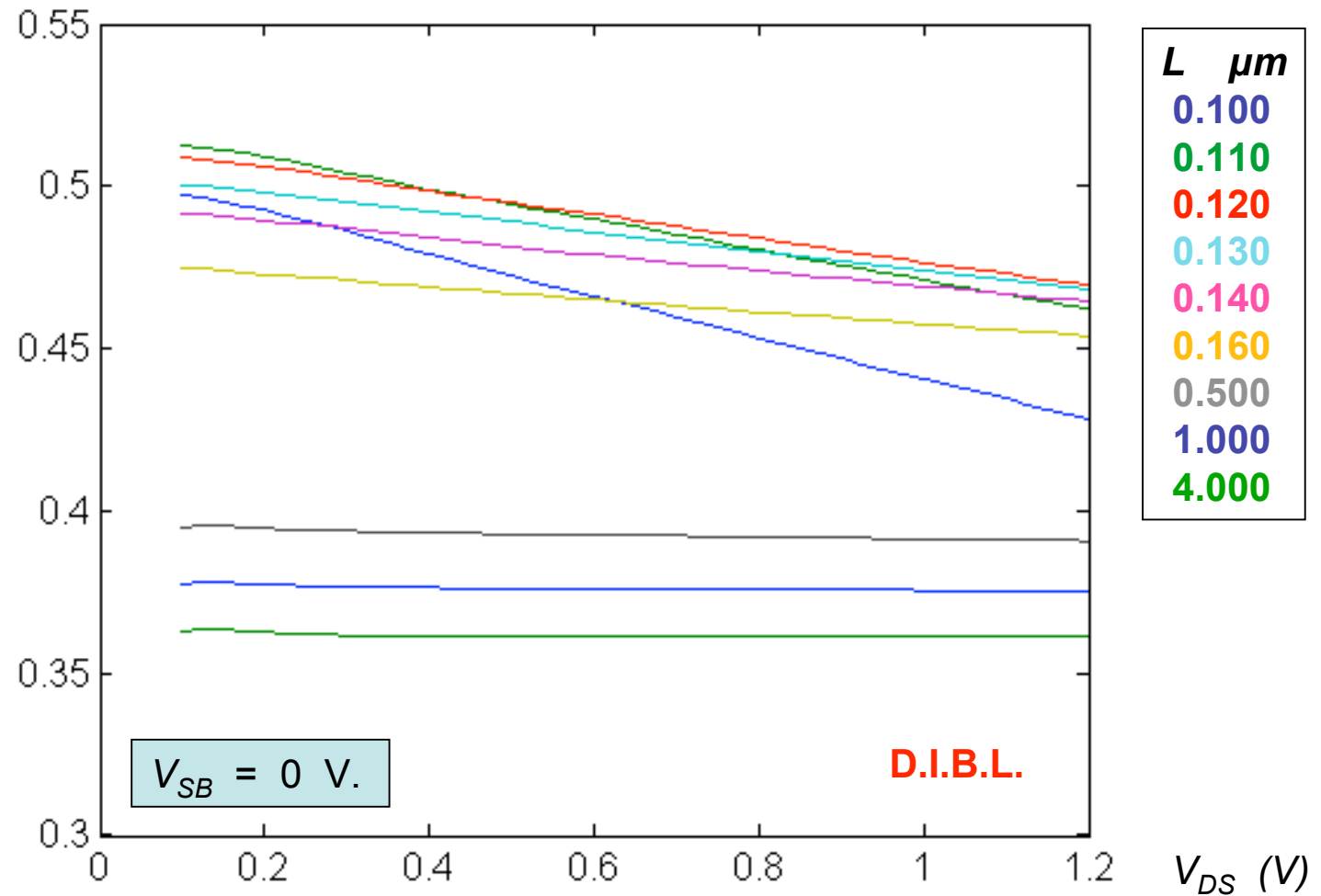
$f_T = 1$ GHz; $C_o = 1$ pf; $L = 120$ nm; $V_S = 0$; $V_{DS} = 0.6$ V; $W_{max} = 1$ μ m;



Param. dependence on V_{DS}

1) n small

2) $V_{To} \rightarrow$

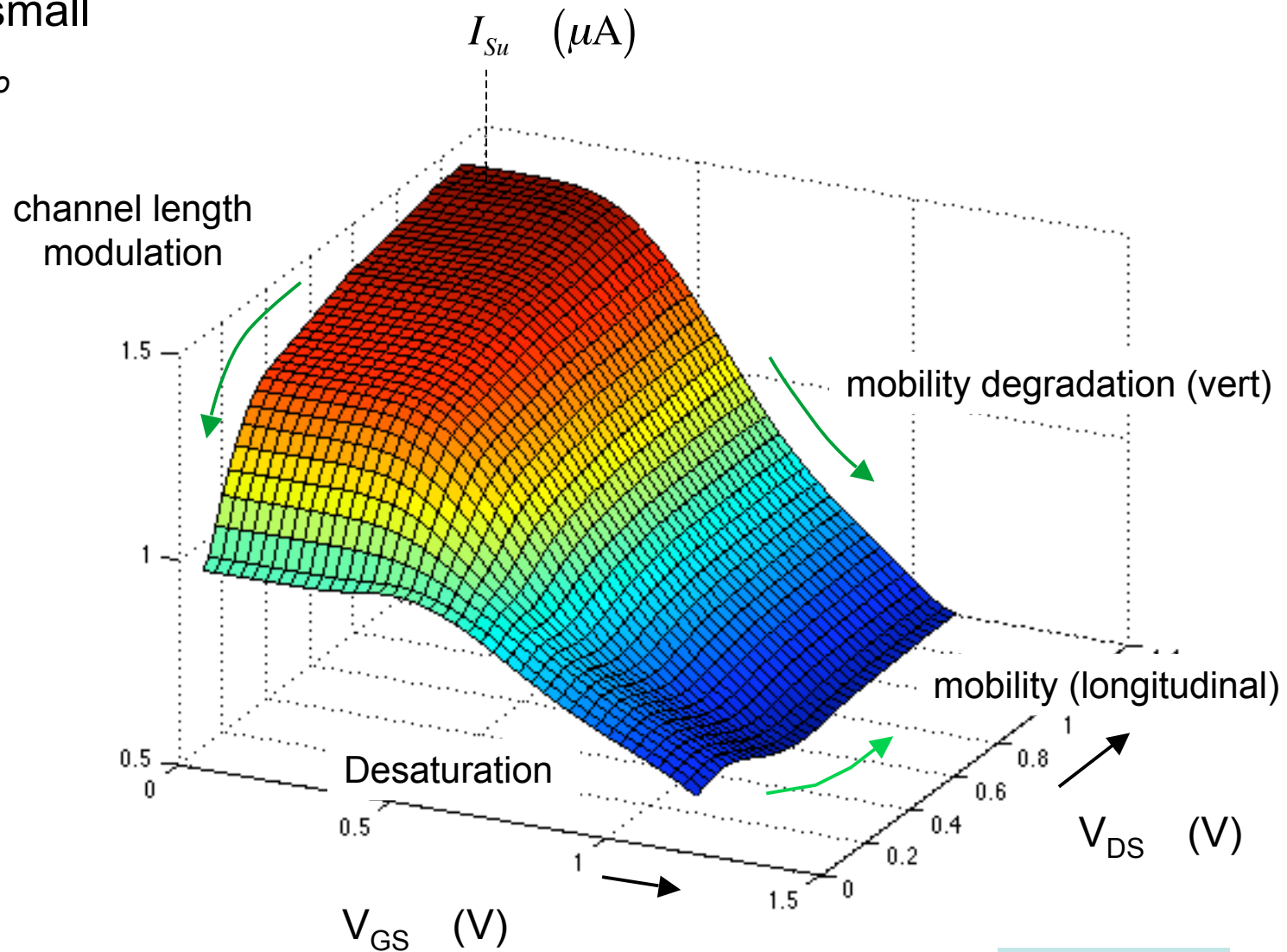


Param. dependence on V_{DS}

1) n small

2) V_{To}

3) I_{Su}



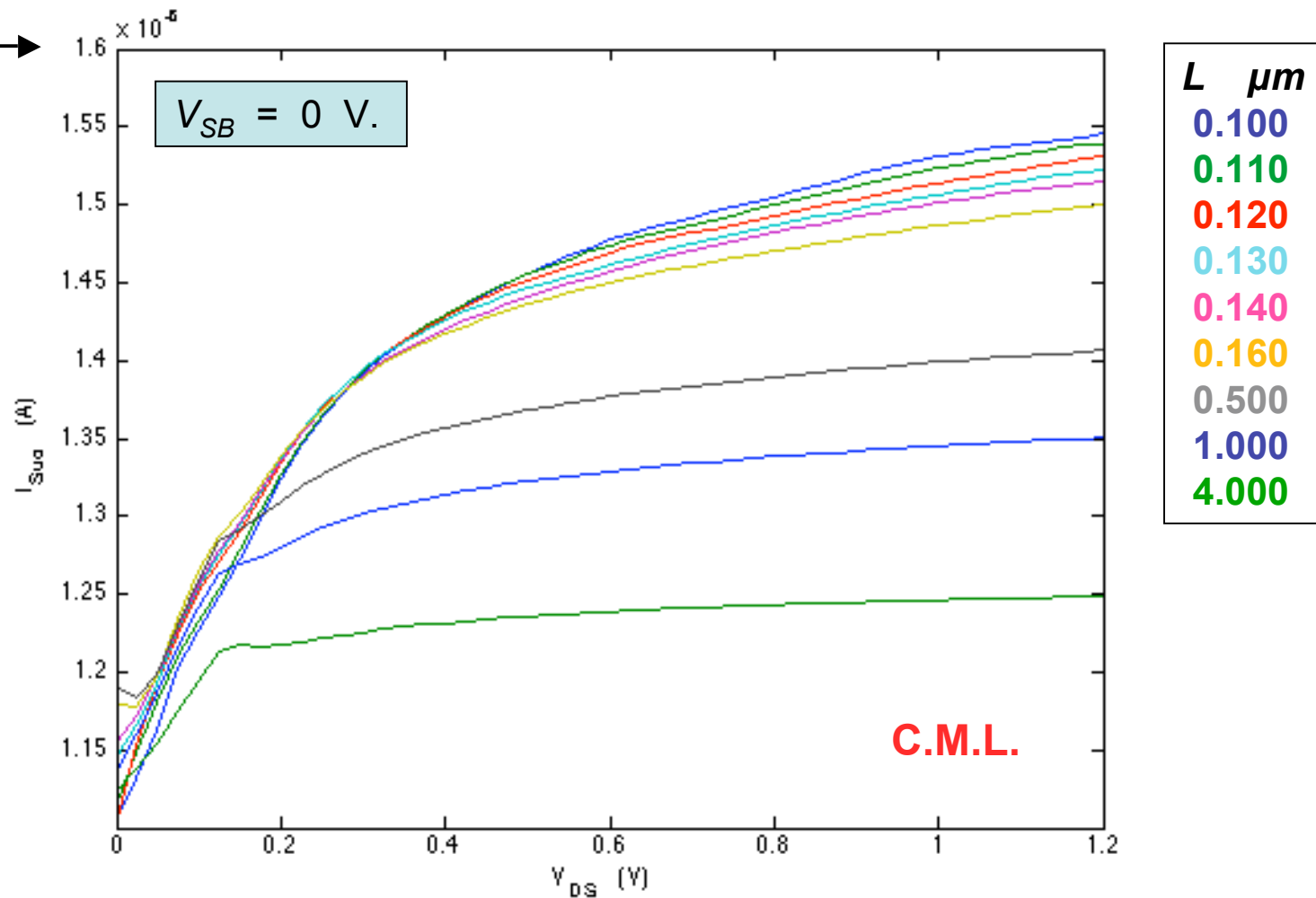
$$V_{SB} = 0 \text{ V.}$$

Param. dependence on V_{DS}

1) n small

2) V_{To}

3) I_{Suo} →



Param. dependence on V_{DS}

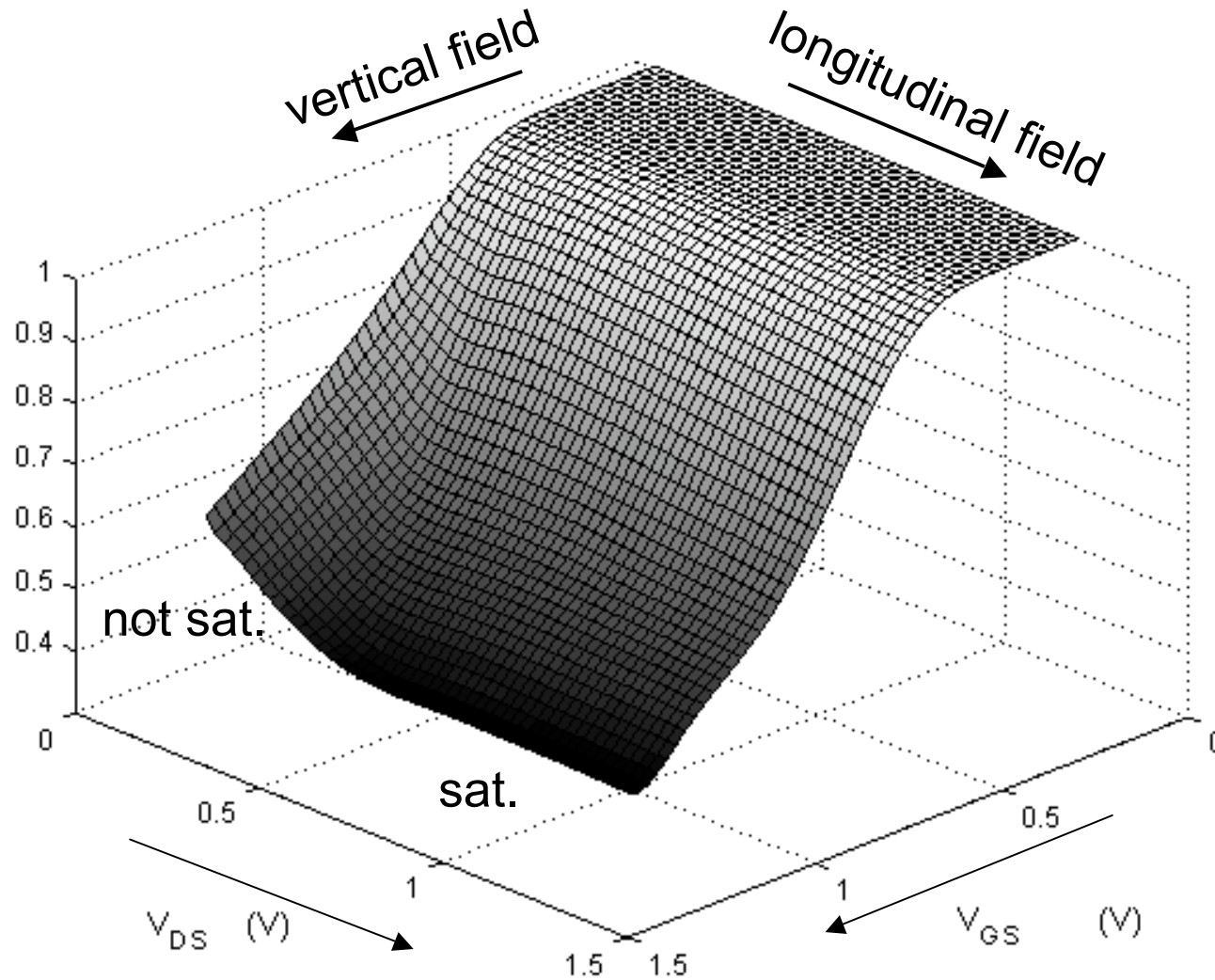
1) n small

2) V_{To}

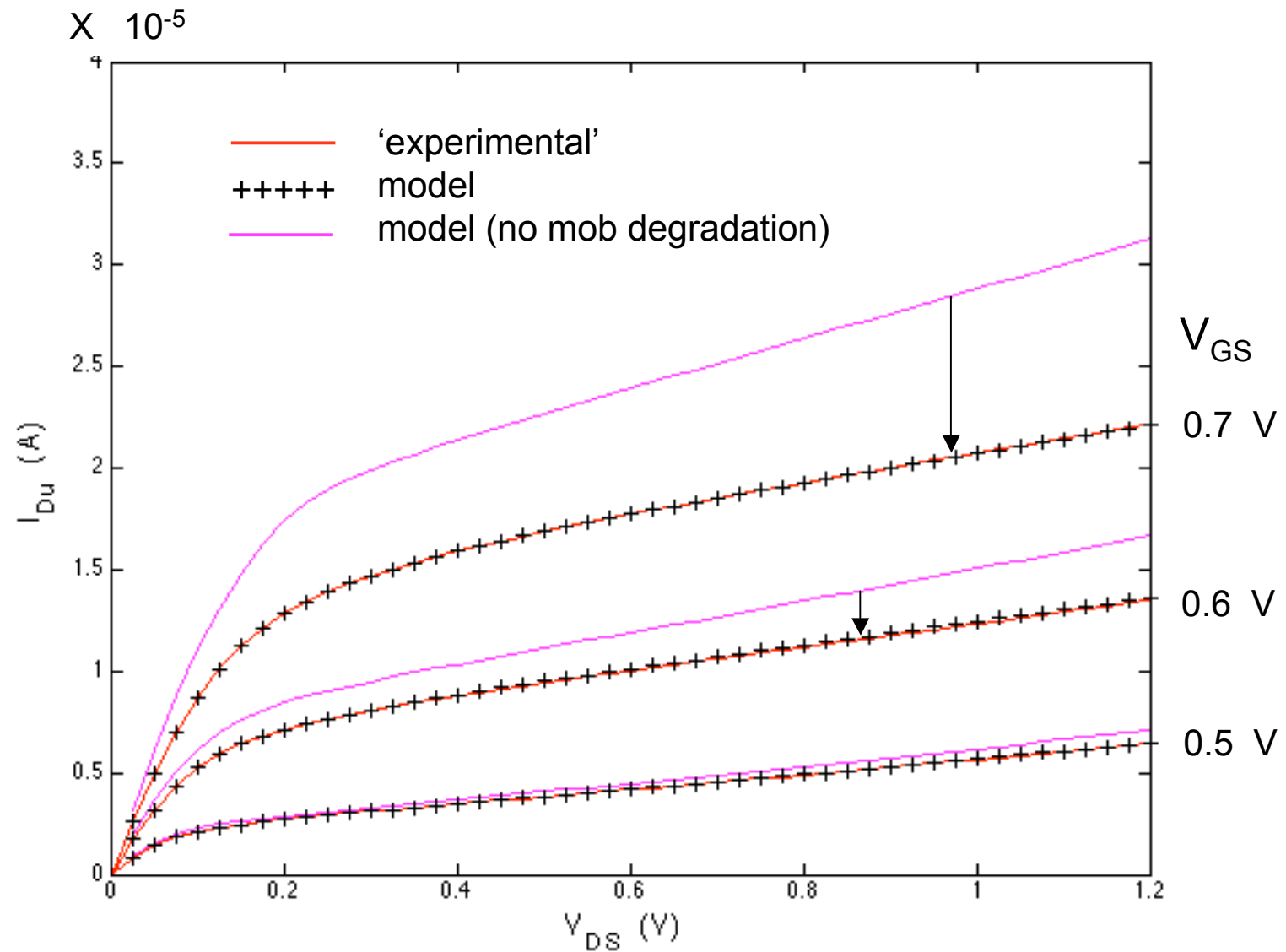
3) I_{suo}

4) $\theta(i) \rightarrow$

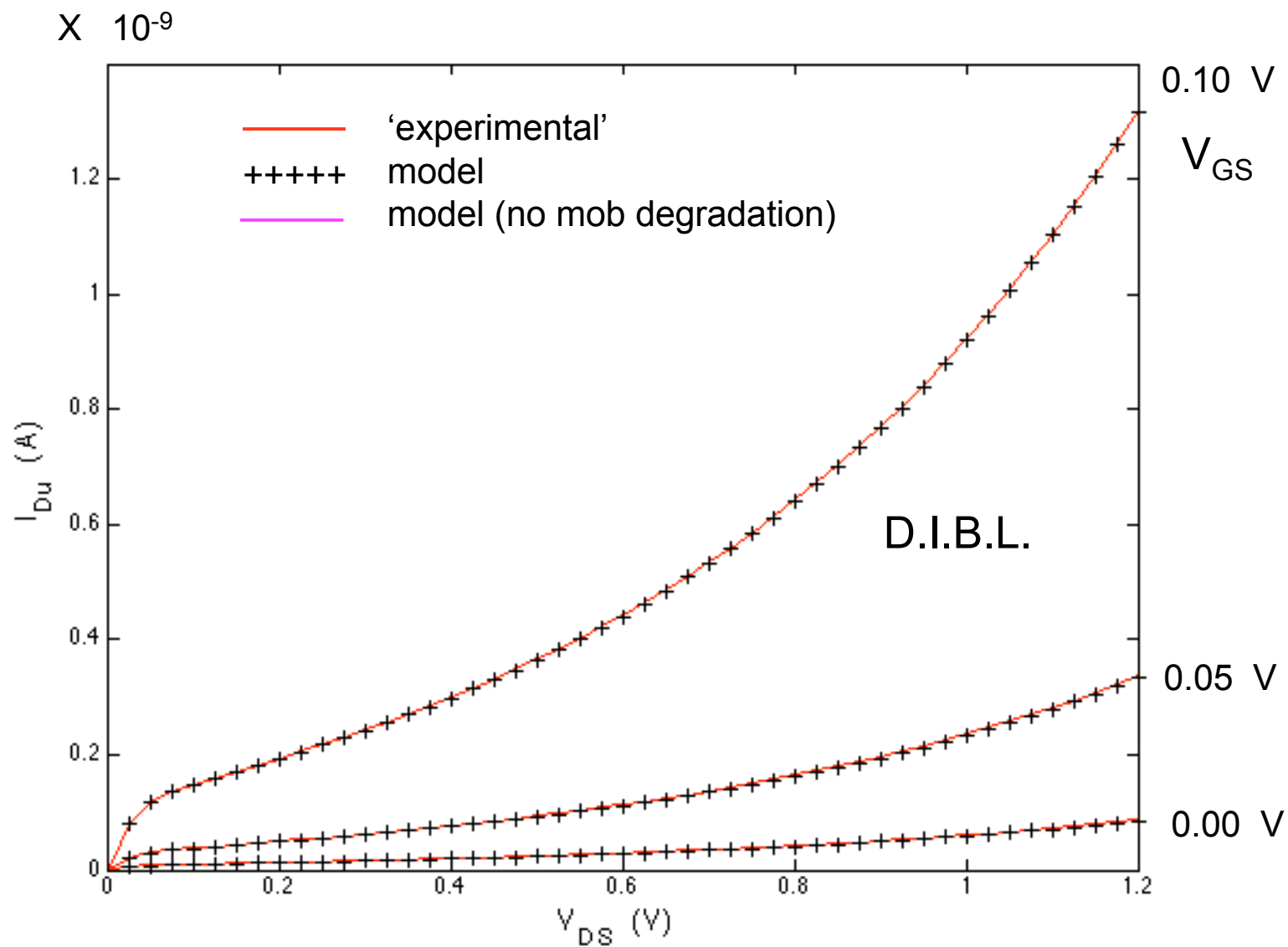
$V_{SB} = 0 \text{ V.}$



Verification : $I_{Du}(V_{DS})$ reconstruction (S.I.)



Verification : $I_{Du}(V_{DS})$ reconstruction (W.I.)



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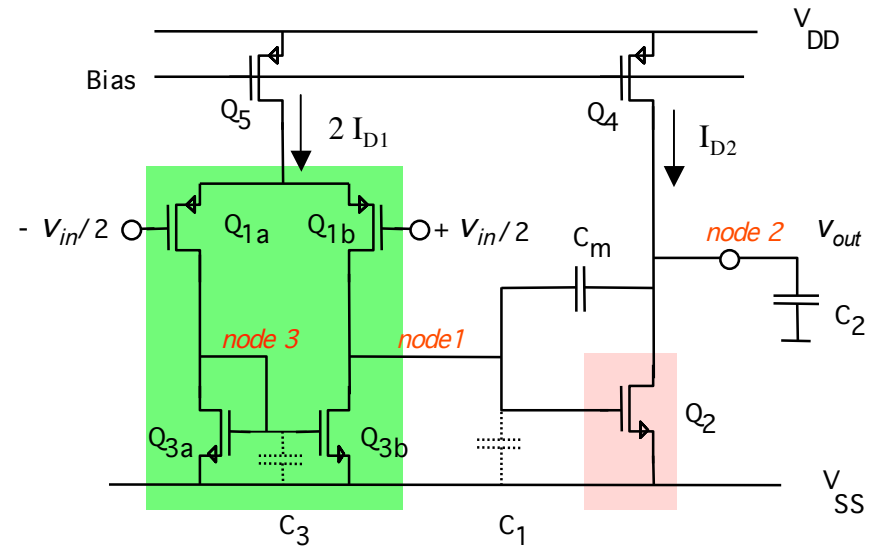
Conclusion

1) fix **NDP**ole and **Z**ero with respect to ω_T to meet phase margin

$$\omega_T = \frac{g_{m1}}{C_m}$$

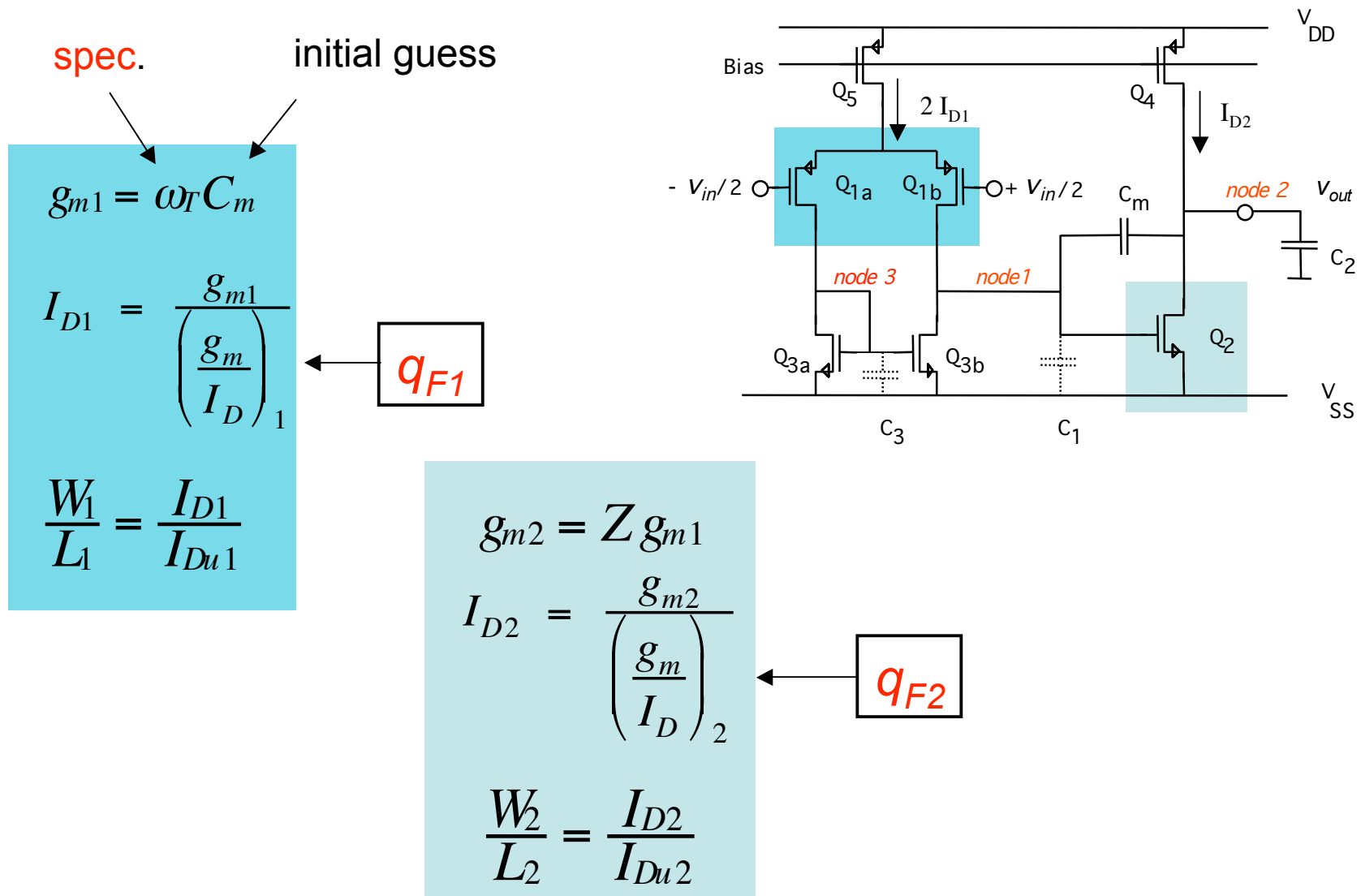
$$z = \frac{g_{m2}}{C_m} = \mathbf{Z} \omega_T$$

$$\omega_{ndp} = \frac{g_{m2}}{C_m} \frac{C_m^2}{(C_1 + C_2)C_m + C_1 C_2} = \mathbf{NDP} \omega_T$$



e.g. $Z = 10$ and $NDP = 4 \dots 5$
for phase margin of approx. 60°

2) Size the 'A' transistors.



3) Size the 'B' transistors.

more constraints

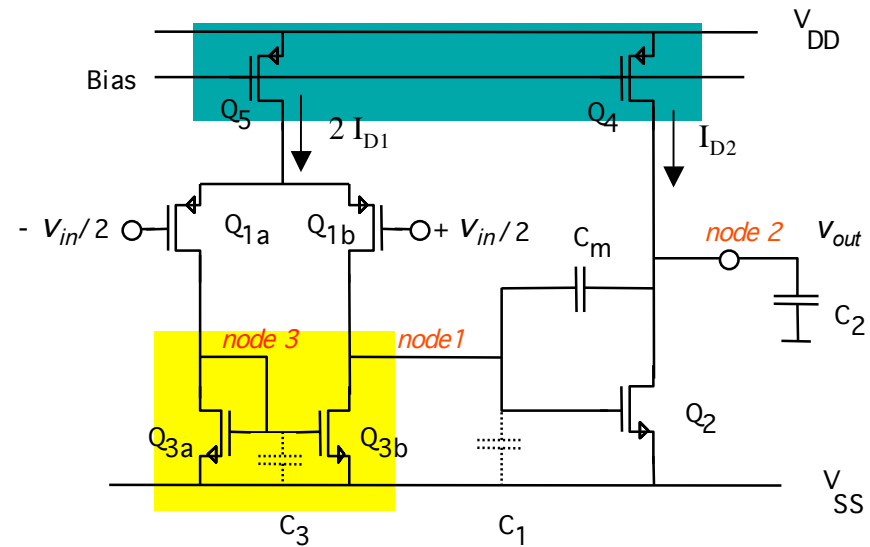
- zero systematic offset

$$V_{G3} = V_{G2}$$

$$\left(\frac{W}{L}\right)_3 = \frac{I_{D1}}{I_{Du2}}$$

- choose bias so that Q4 and Q5 are in strong inversion

$$I_{Du4} = I_{Du5}$$



$$\left(\frac{W}{L}\right)_4 = \frac{I_{D2}}{I_{Du4}}$$

$$\left(\frac{W}{L}\right)_5 = \frac{2I_{D1}}{I_{Du4}}$$

4) Estimate C_1 , C_2 , C_3 and compute C_m

Choose ...

- L_1 medium (voltage gain)
- L_2 min. size
- L_3 large for min 1/f noise (beware from doublet!)
- L_4 matching + size
- L_5 matching + common mode rejection

- the parasitic cap. are estimated knowing W's and L's + techno. data
- a new C_m is extracted from inverted NDP equation

$$C_m = 0.5 \frac{NDP}{Z} \cdot \left[C_1 + C_2 + \sqrt{(C_1 + C_2) + 4 \frac{Z}{NDP} C_1 C_2} \right]$$

reiterate until C_m gets constant

example

Spec: $f_T = 50 \text{ MHz}$;
 $C = 1 \text{ pF}$;
 $V_{DD} = 1.2 \text{ V}$;

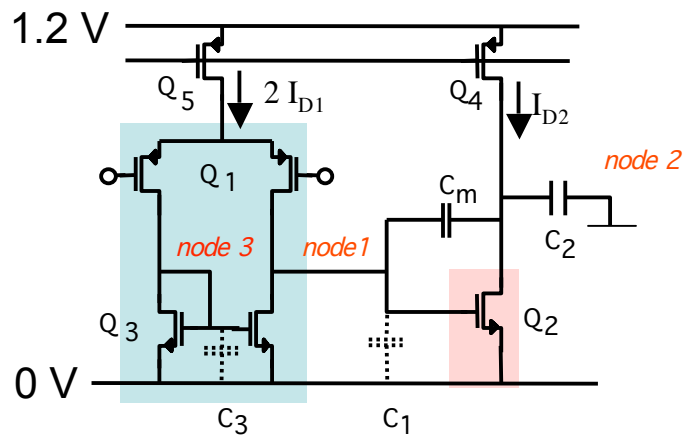
$$\begin{aligned} q_{F1} &= 0.0316 \rightarrow 3.16 \\ q_{F2} &= 0.10 \rightarrow 2 \\ q_{F4} &= 2,90 \end{aligned}$$

q_F exploration
space

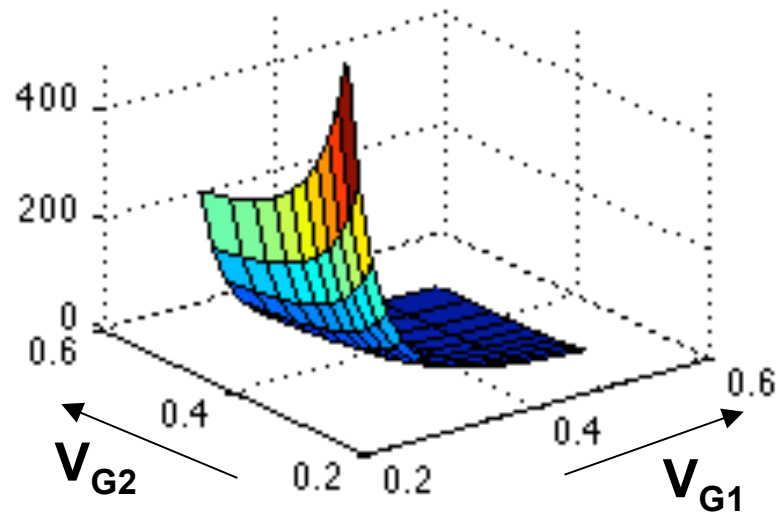
$$\begin{aligned} Z &= 10 \\ \text{NDP} &= 4 \end{aligned}$$

phase
margin

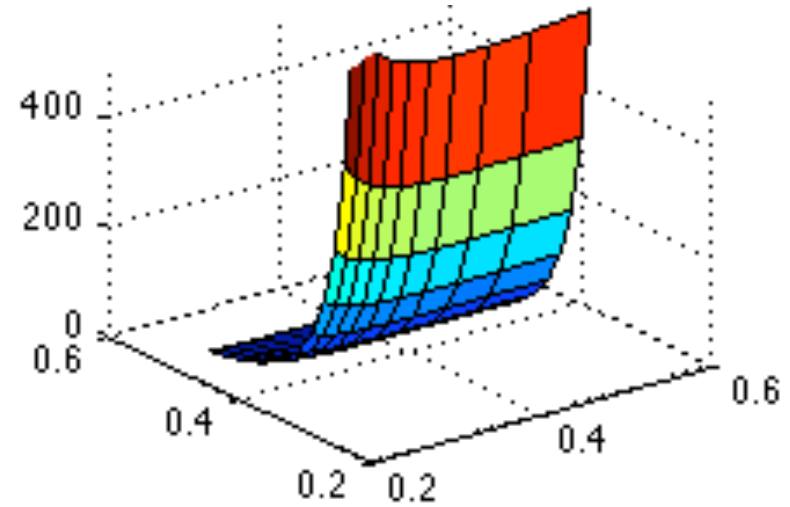
$$\begin{aligned} L1 &= 1 \text{ } \mu\text{m} \\ L2 &= 0.5 \text{ } \mu\text{m} \\ L3 &= 1 \text{ } \mu\text{m} \\ L4 &= 0.5 \text{ } \mu\text{m} \\ L5 &= 1 \text{ } \mu\text{m} \end{aligned}$$



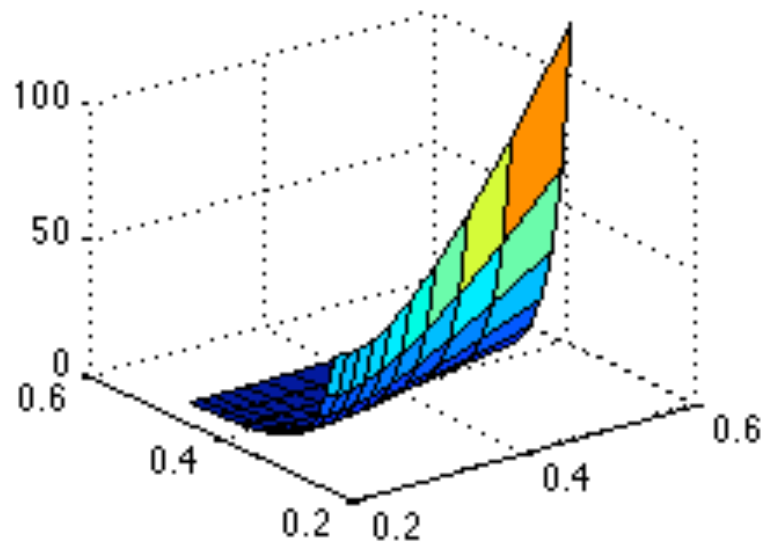
W1



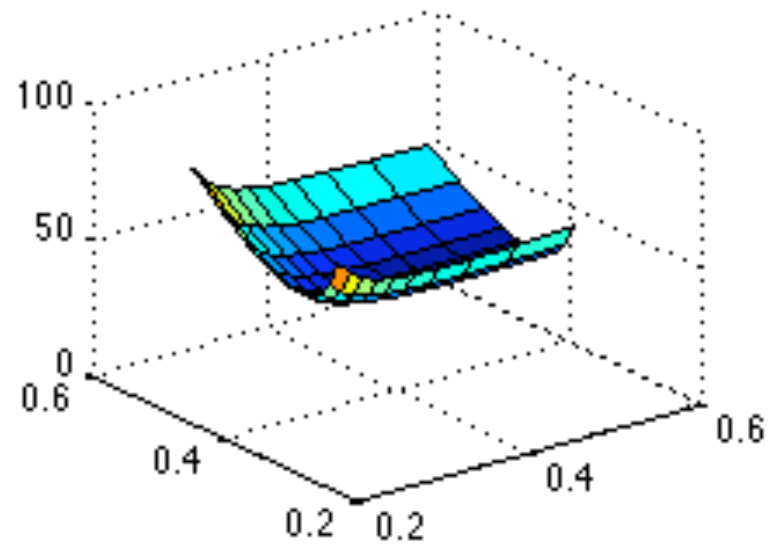
W2

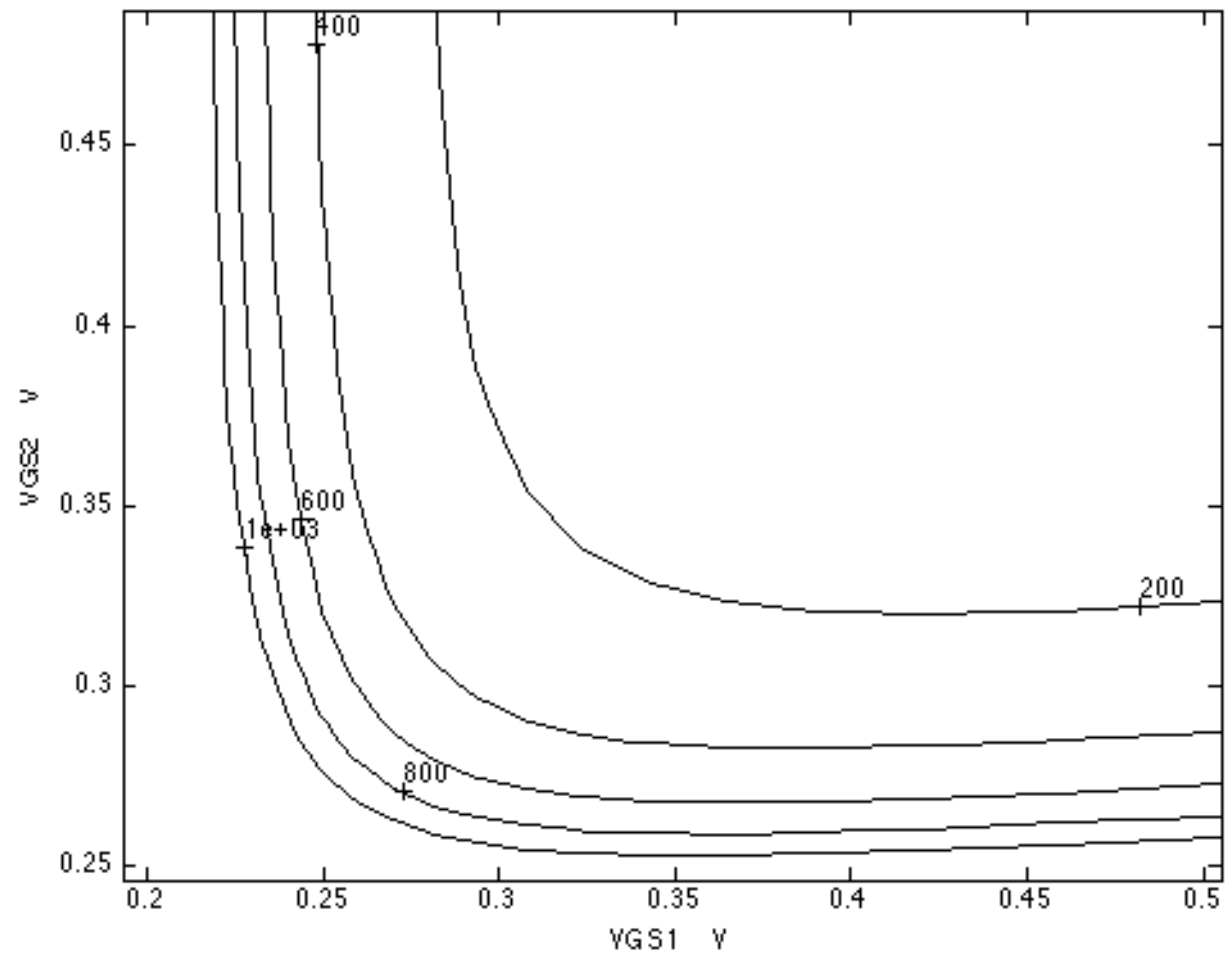


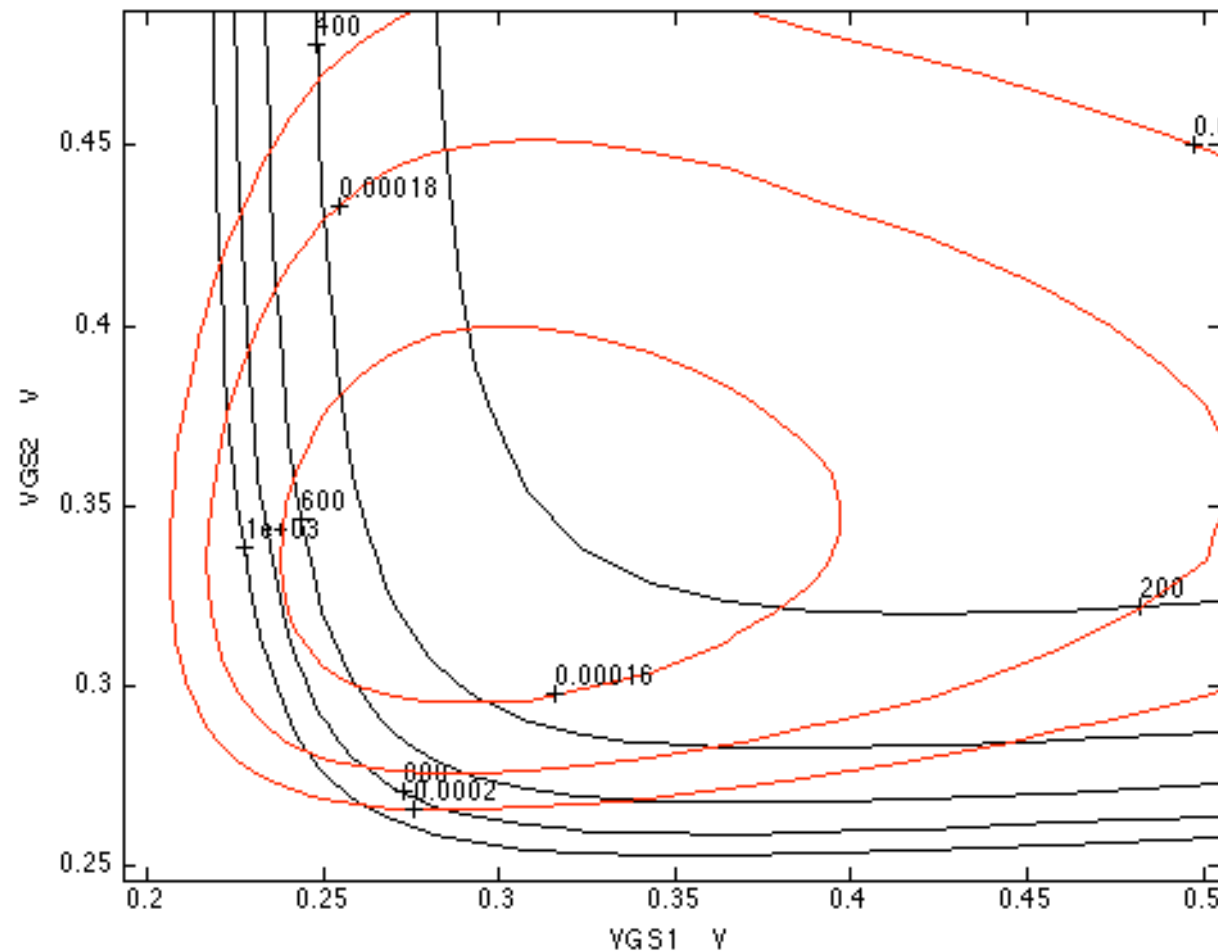
W3



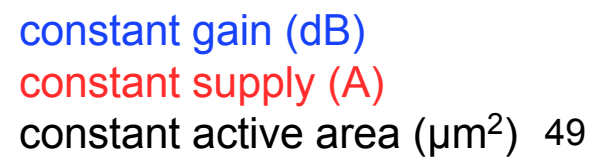
W4

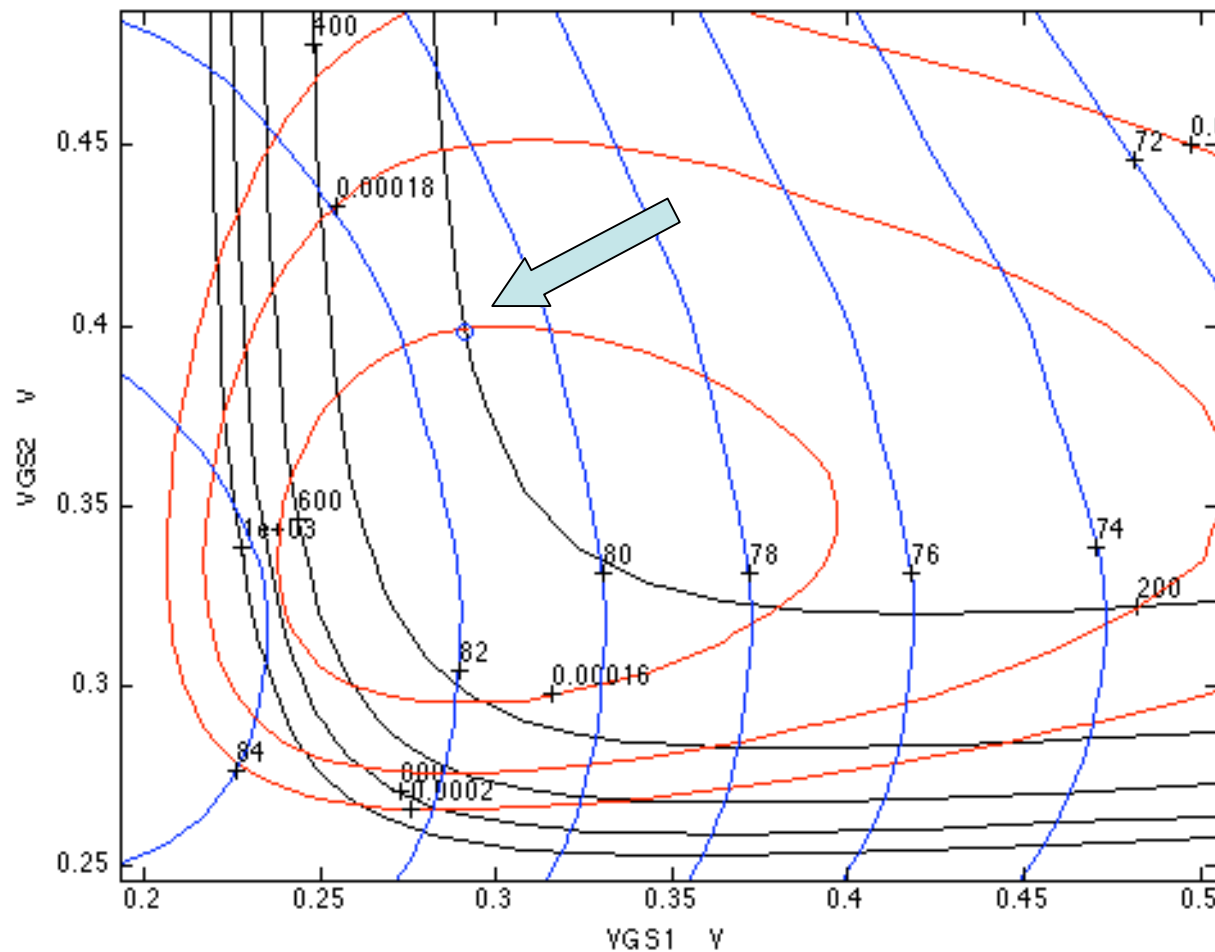






constant supply (A)
constant active area (μm^2) 48



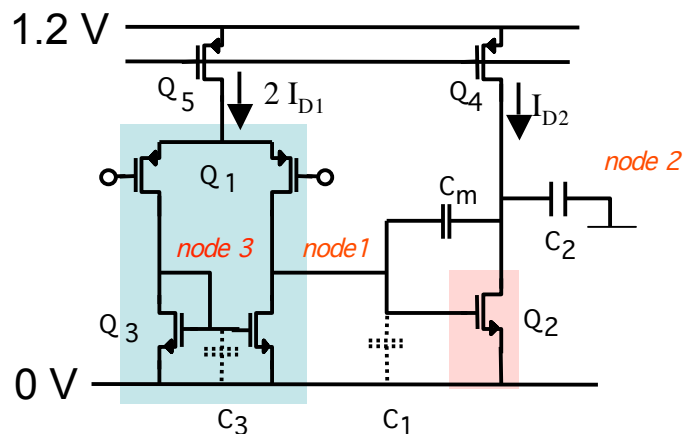


constant gain (dB)
 constant supply (A)
 constant active area (μm^2) 50

The selected point

qF
VGS (V)
I (μ A)
W
L (μ m)
gain (dB)

Q1	Q2	Q3	Q4	Q5
0.433	1.065	1.236	2.90	2.90
0.29	0.40	0.40	0.49	0.49
2 x 8.1	143.7	2 x 8.1		
67.3 1	47.5 0.5	2.23 1	57.83 0.5	7.69 1
45.1	39.2			
0.1965 C1 pF	1.0375 C2 pF	0.0576 C3 pF	0.6242 Cm pF	



gain = 81 dB

power consump. = 191 μ W

Conclusion

$$g_m/I_D$$

- relates a small signal param. to a large signal quantity
- does not vary with transistor widths
- controls the mode of operation, power consump, gain ...

paves the way for sizing CMOS circuits

- semi-empirically
(look-up tables : I_D , g_m , g_d , ..)
- by means of the E.K.V./A.C.M. model
(parameters look-up tables or fitting functions)
 - simple expressions of I_D , g_m/I_D , g_d/I_D
 - q_F monitors mode of operation
 - increased physical insight

suitable for sub-micron low-voltage low-power circuits

g_m/I_D sizing methodology for low-power/voltage CMOS circuits

by P.G A. Jespers

to be published 2009 by Springer

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